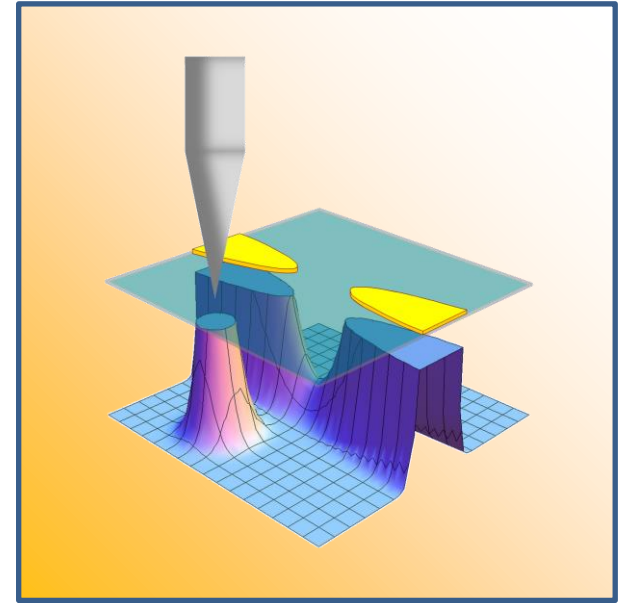


# Scanning Gate Microscopy on low-dimensional nanostructures



**Stefan Heun**

*NEST, Istituto Nanoscienze-CNR and  
Scuola Normale Superiore, Pisa, Italy*

# NEST Pisa



National Enterprise for nanoScience and nanoTechnology

# NEST

# Research themes @ NEST Pisa

National Enterprise for nanoScience and nanoTechnology

NEST is an interdisciplinary research and training centre where physicists, chemists and biologists investigate scientific issues at the nanoscale.

## NanoPhysics

1. Quantum transport and phase coherent effects in superconductors
2. Physics of low-dimensional semiconductor systems
3. Graphene (**Flagship**)

## Advanced Photonics

1. Intersubband polaritonics
2. Silicon-Germanium optoelectronics
3. THz photonics
4. OptoElectronics Materials: from nanoscale to bulk single crystals

## NanoBioScience

1. Visualizing brain function and structure in the living mouse
2. Lab-on-a-chip technologies
3. Nanoscale and single-molecule spectroscopy and imaging of soft matter



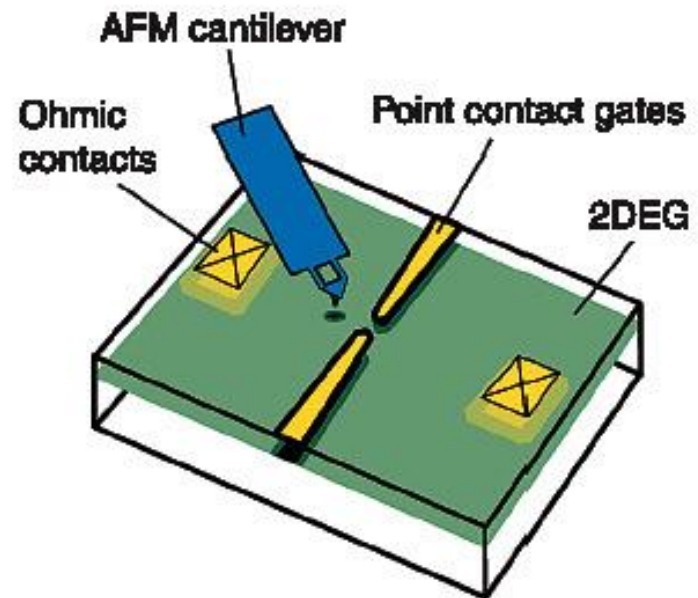
- **Basics of Scanning Gate Microscopy (SGM)**
- **0.7 Anomaly in Quantum Point Contacts**
- **Ongoing Activities**



- **Basics of Scanning Gate Microscopy (SGM)**
- **0.7 Anomaly in Quantum Point Contacts**
- **Ongoing Activities**

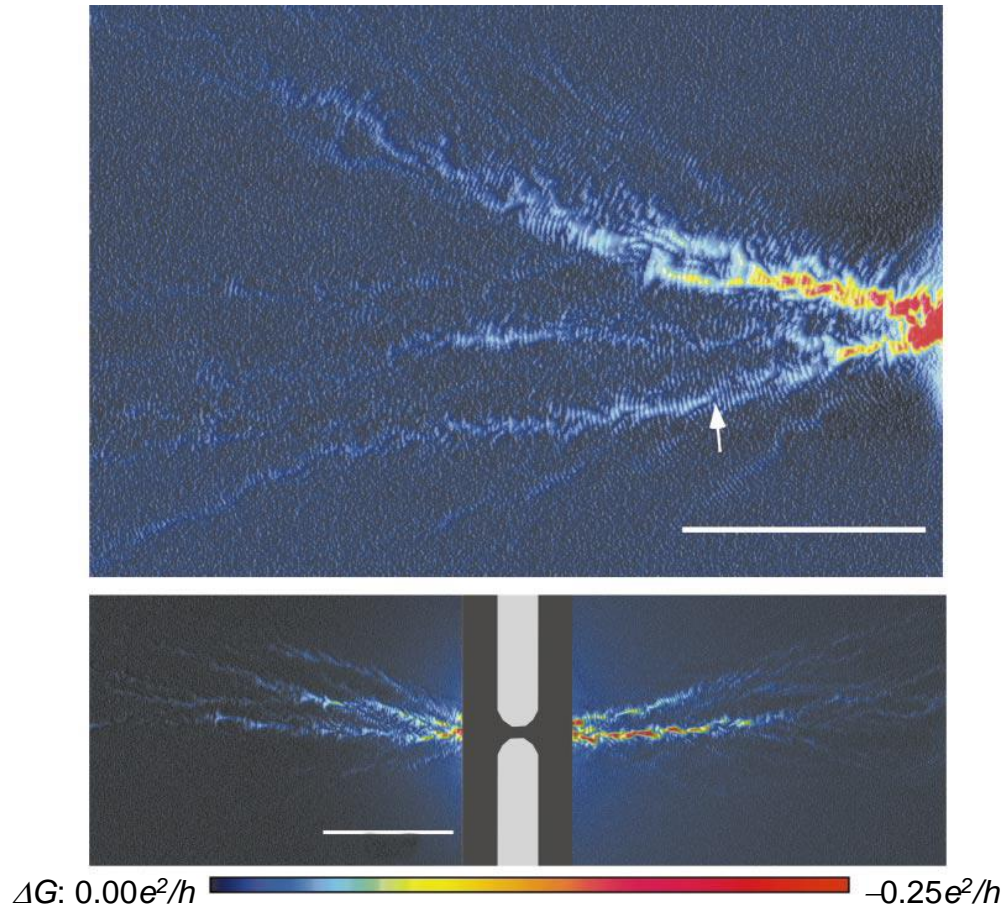
# Scanning Gate Microscopy

- AFM with conductive tip
- SGM performed in constant height mode (10-50 nm above surface), no strain
- Tip at negatively bias (local gate - locally depletes the 2DEG), no current flows

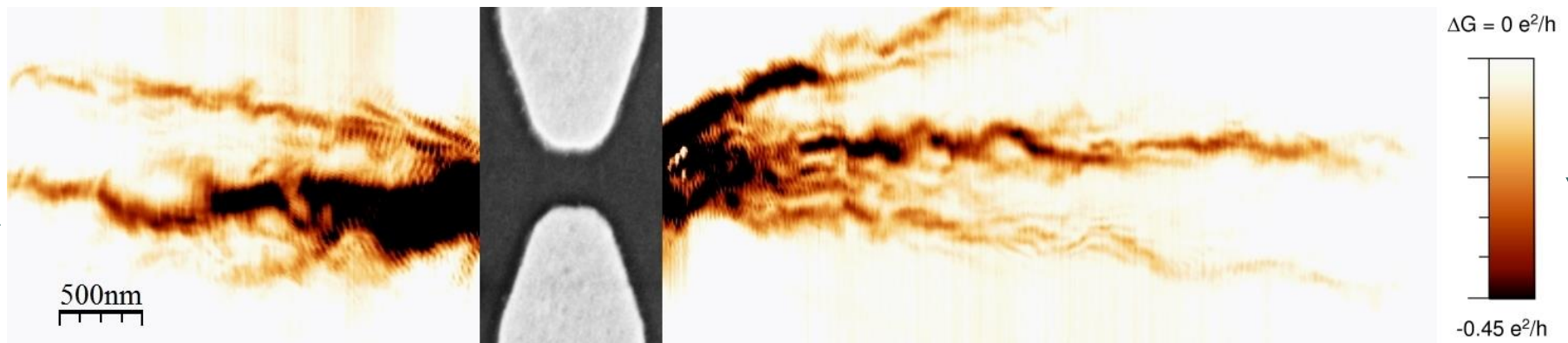


M. A. Topinka et al.:  
Science **289** (2000) 2323.

# Coherent branched flow of electrons

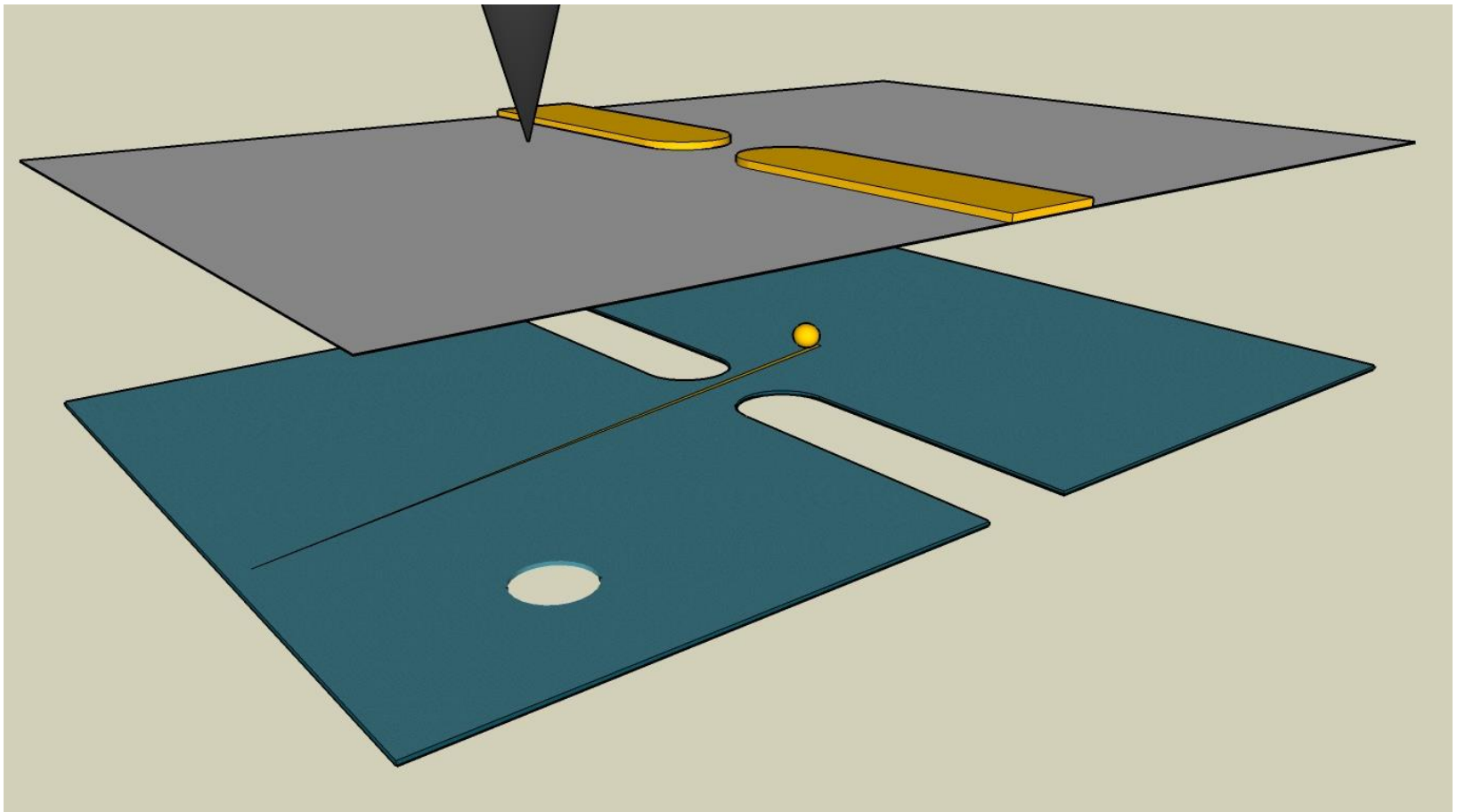


# Branched flow of electrons



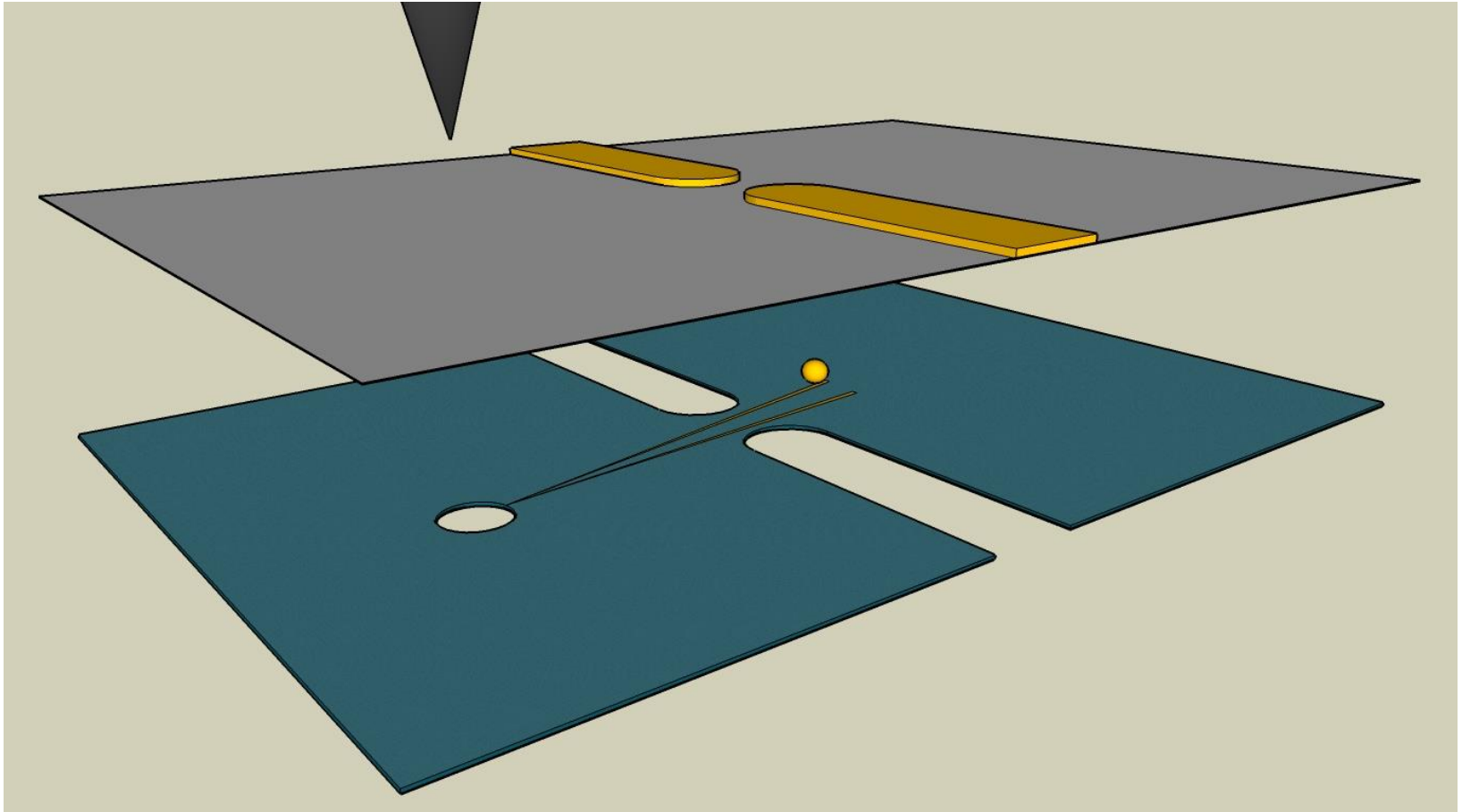
- No magnetic field ( $B = 0$ )
- QPC conductance  $G = 6 e^2/h$  (3<sup>rd</sup> plateau)
- Tip voltage  $V_{\text{tip}} = -5 \text{ V}$ , height  $h_{\text{tip}} = 10 \text{ nm}$

# Tip-induced backscattering

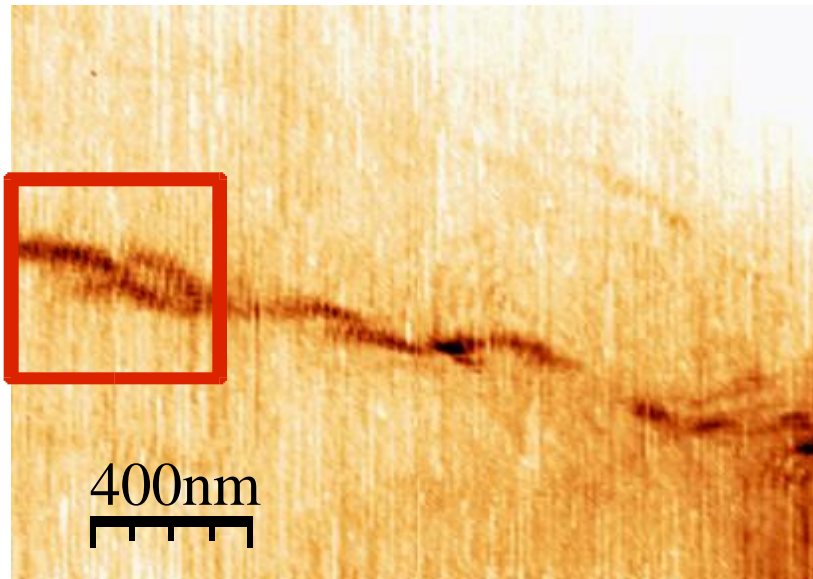
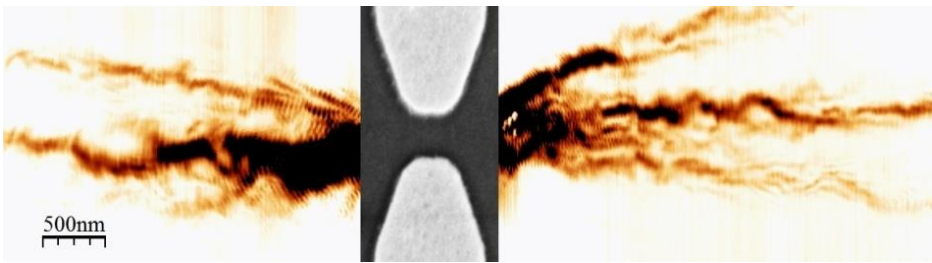




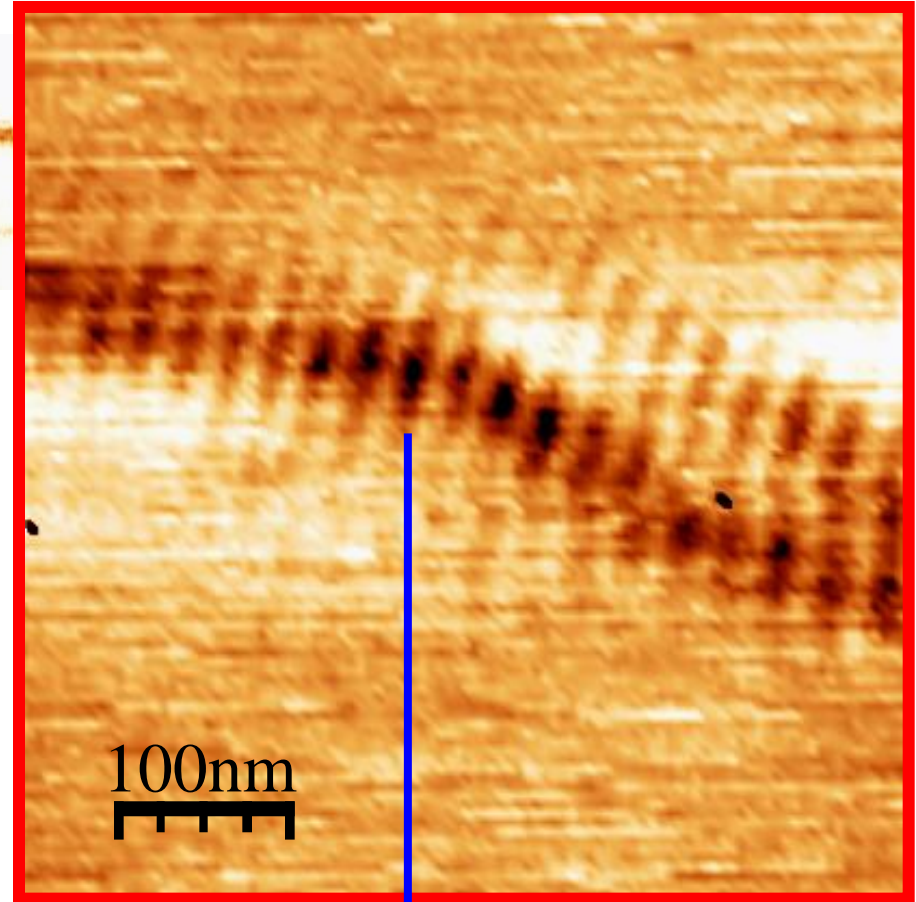
# Tip-induced backscattering



# Branched flow and interference fringes



- QPC conductance  $G = 6 e^2/h$  (3<sup>rd</sup> plateau)
- Tip voltage  $V_{\text{tip}} = -5$  V, height  $h_{\text{tip}} = 10$  nm



Fringe periodicity:  $\lambda_F/2 = 20$  nm

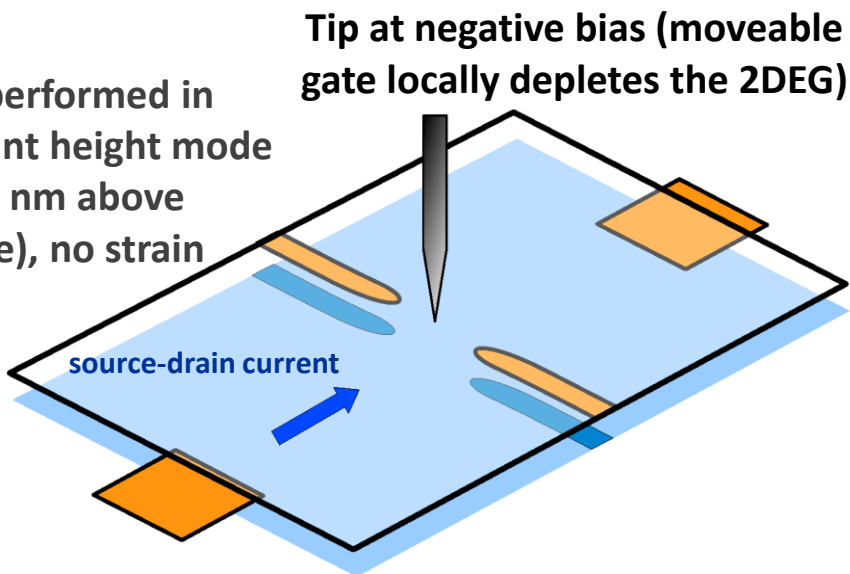
N. Paradiso *et al.*, *Physica E* 42 (2010) 1038.

# The SGM @NEST lab in Pisa

## Setup:

- AFM non-optical detection scheme (tuning fork)
- With vibration and noise isolation system
- $^3\text{He}$  insert (cold finger base temp.: 300 mK)
- 9 T cryomagnet

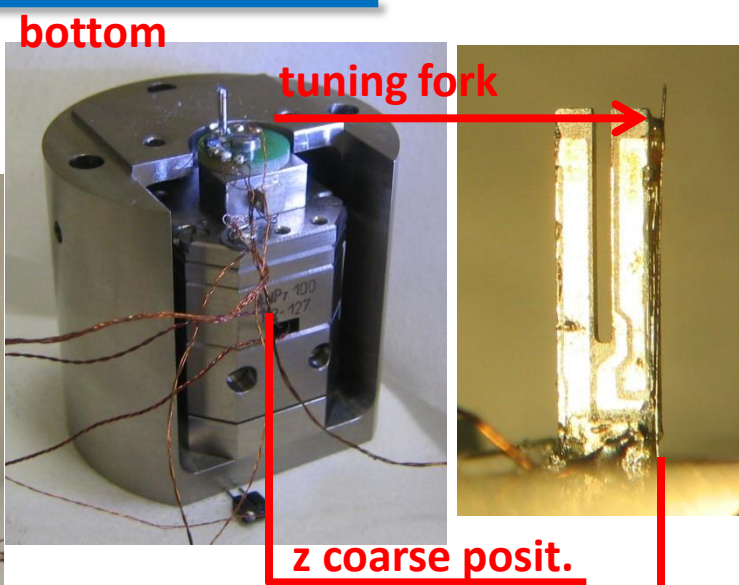
SGM performed in constant height mode (10-50 nm above surface), no strain



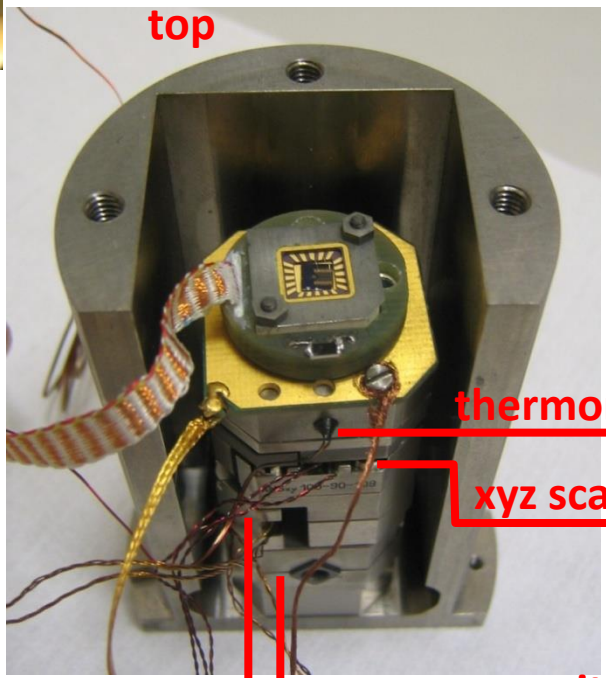
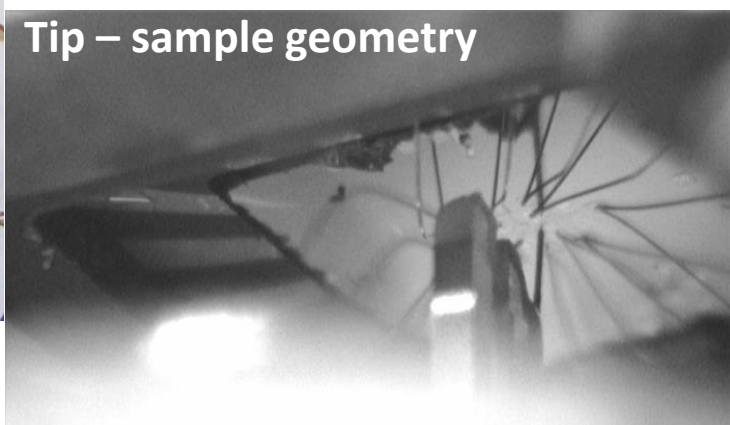
 **attocube systems**  
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# Tuning fork and sample holder



conductive tip glued on the TF



- **Basics of Scanning Gate Microscopy (SGM)**
- **0.7 Anomaly in a Quantum Point Contact**
- **Ongoing Activities**



# Coworkers



A. Igallo



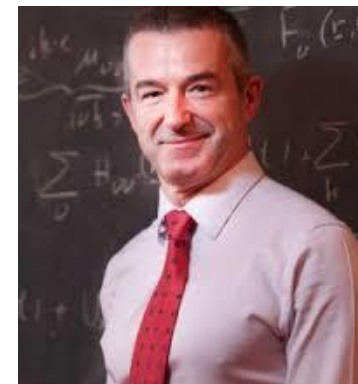
N. Paradiso



S. Roddaro



L. Sorba

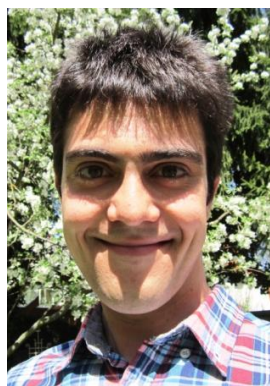


F. Beltram

# Coworkers



A. Igallo



N. Paradiso



S. Roddaro



L. Sorba



F. Beltram

## Materials from:

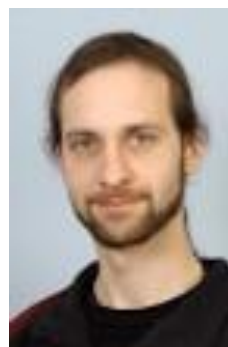
Laboratorio TASC, Trieste, Italy:

Giorgio Biasiol

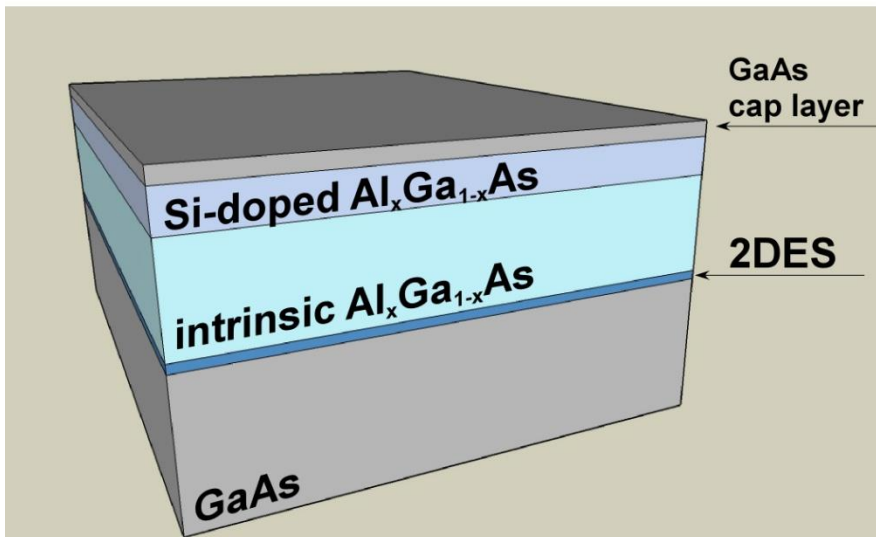


ETH Zurich, Switzerland:

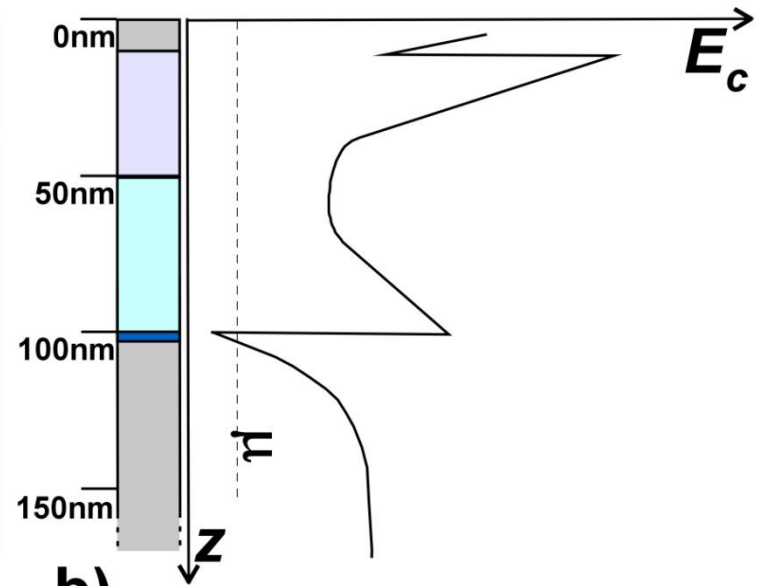
Christian Reichl, Werner Wegscheider



# 2 Dimensional Electron System



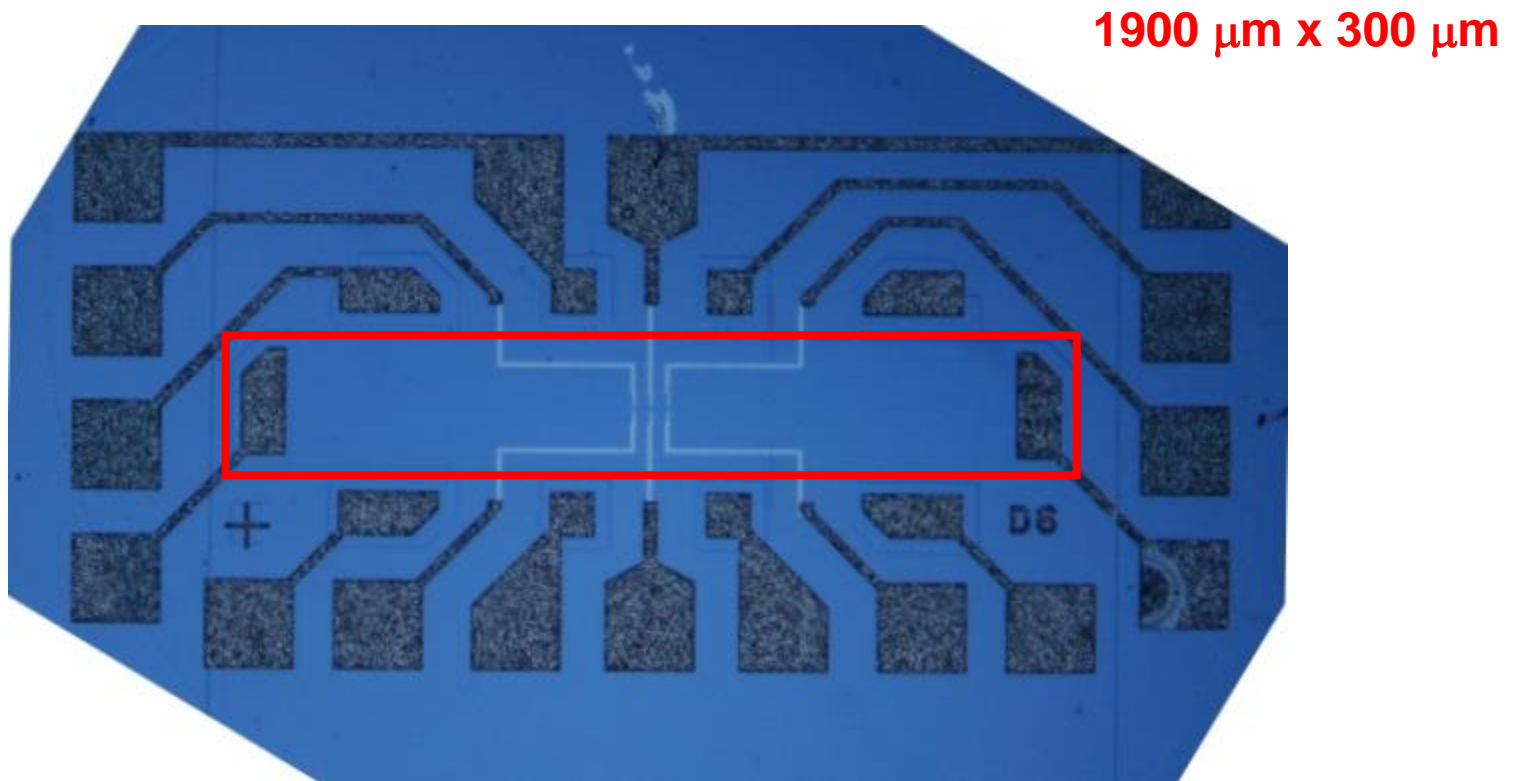
a)



b)

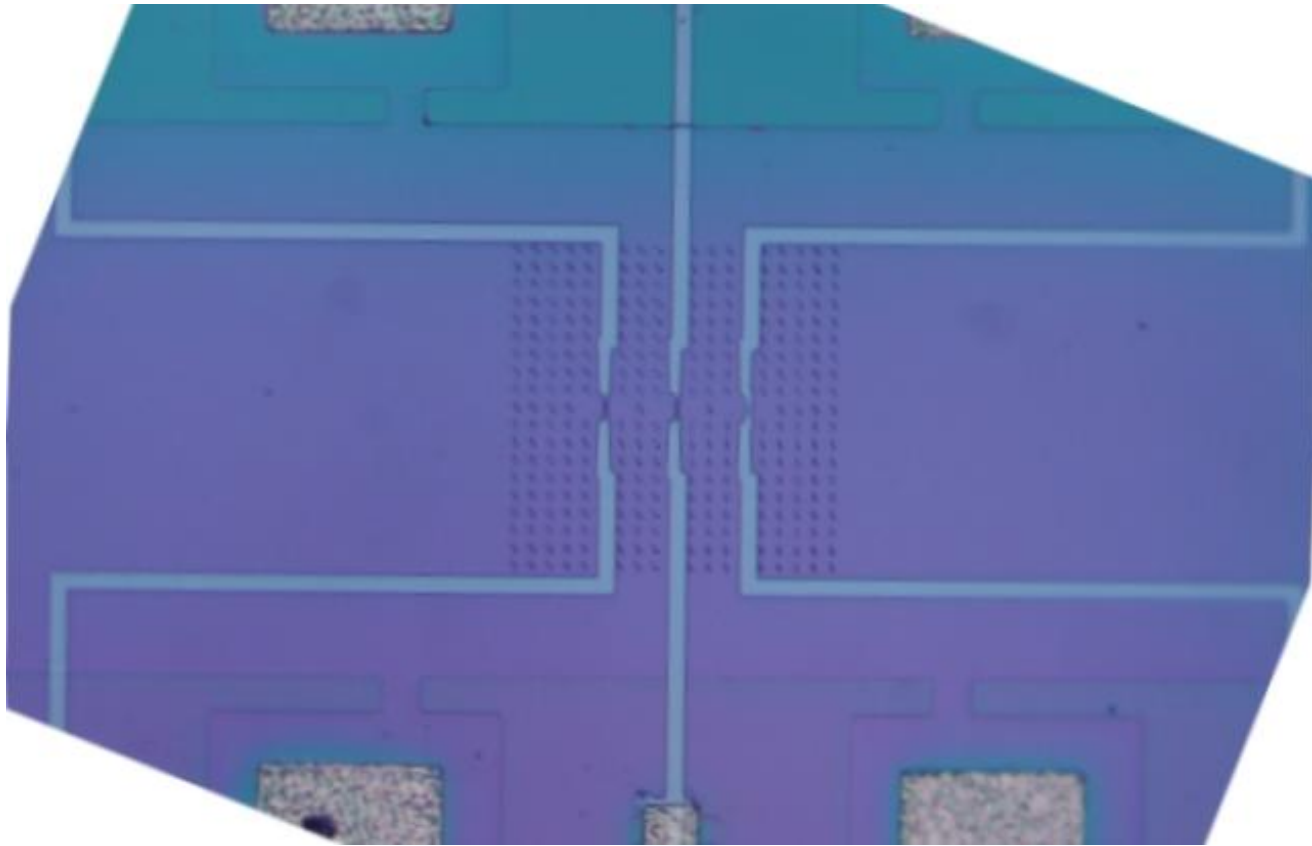
# Hall-bar samples

---



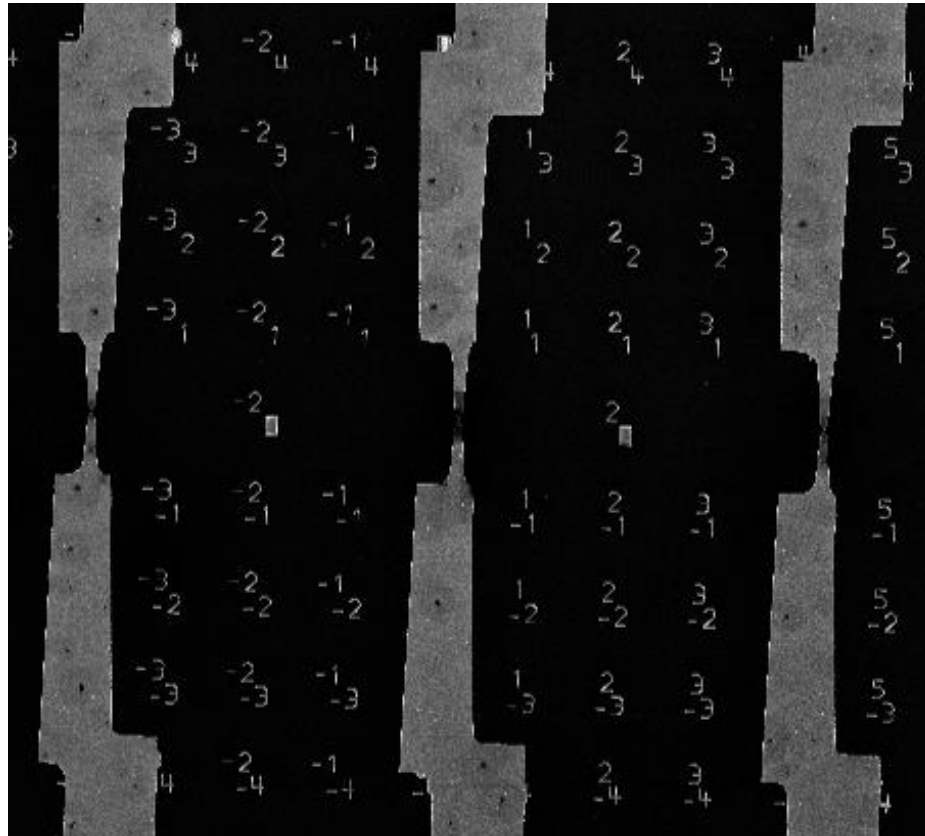
# Hall-bar samples

---

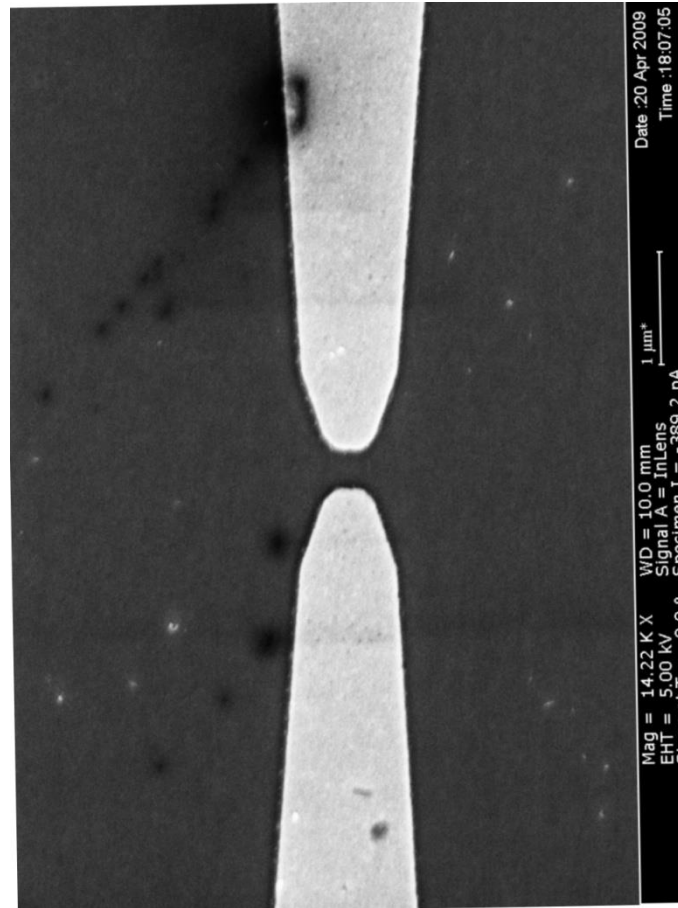




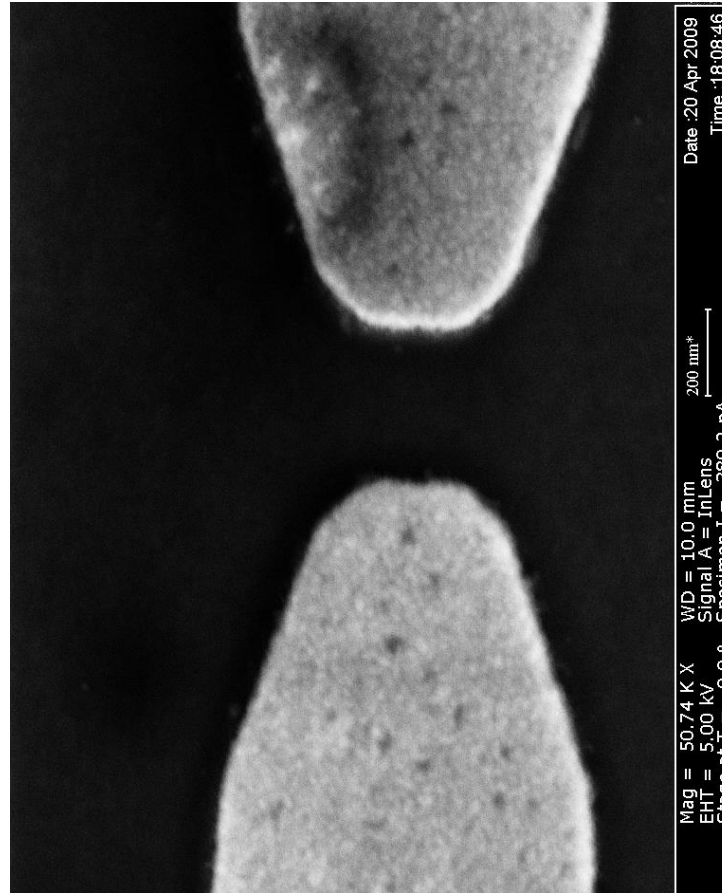
# Hall-bar samples



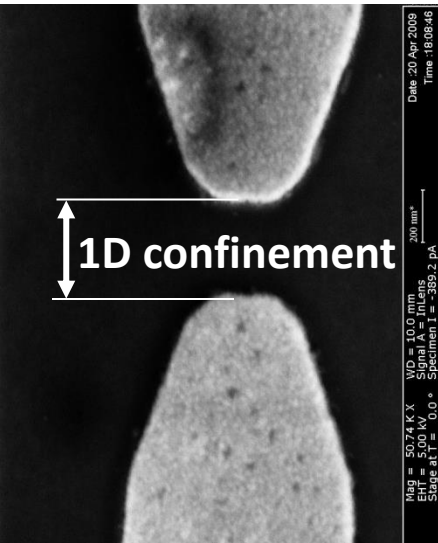
# Hall-bar samples



# Hall-bar samples

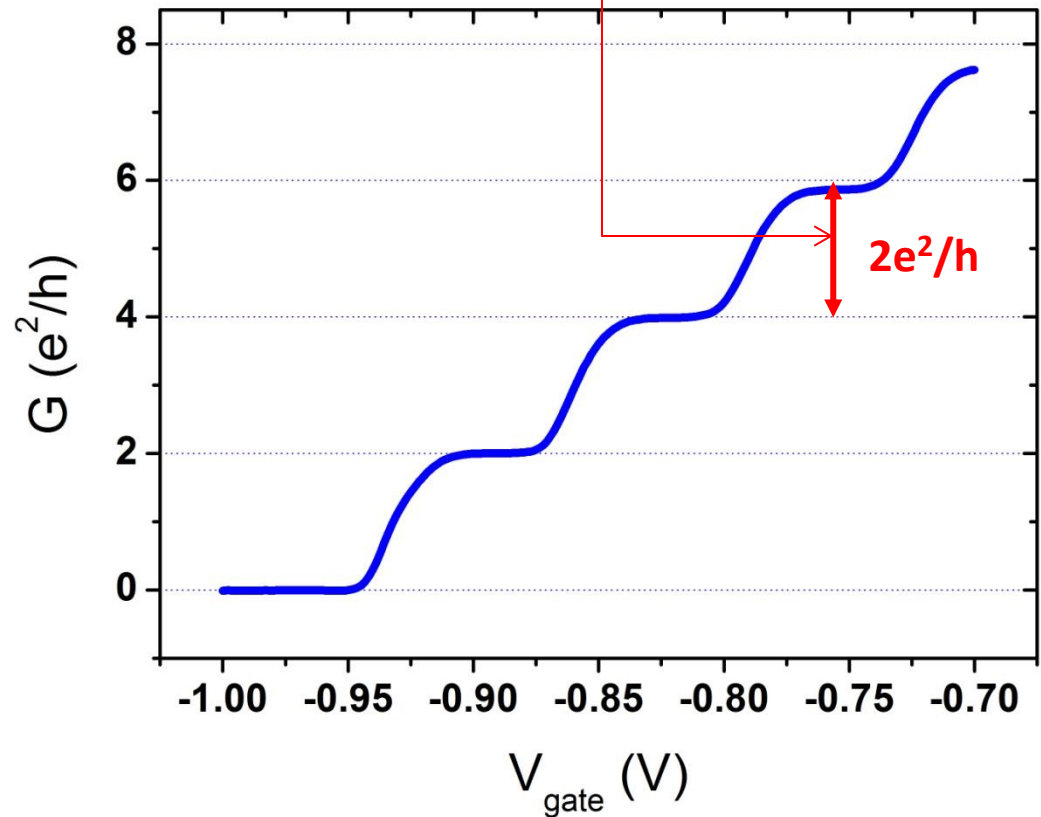


# Conductance quantization in QPCs

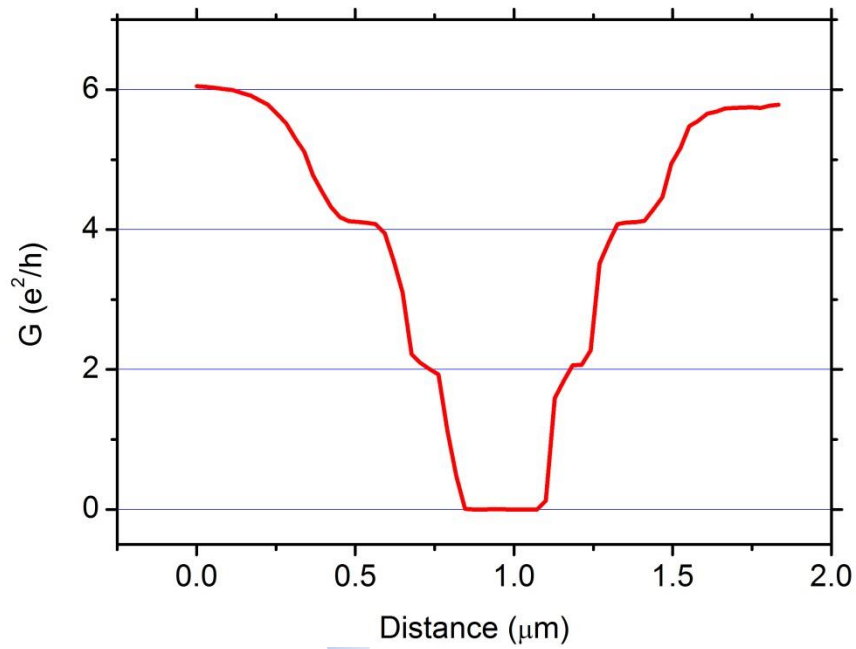
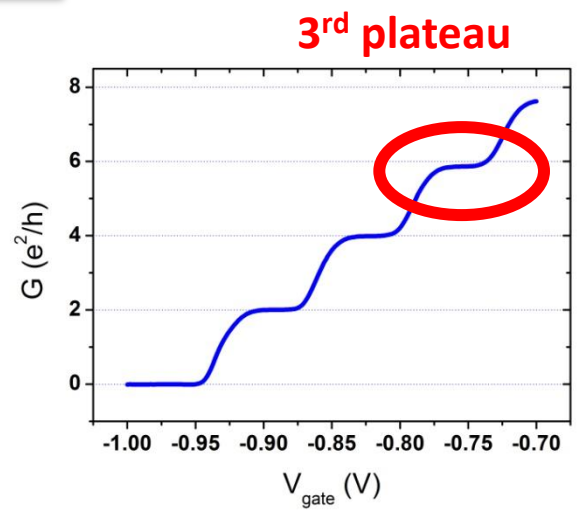
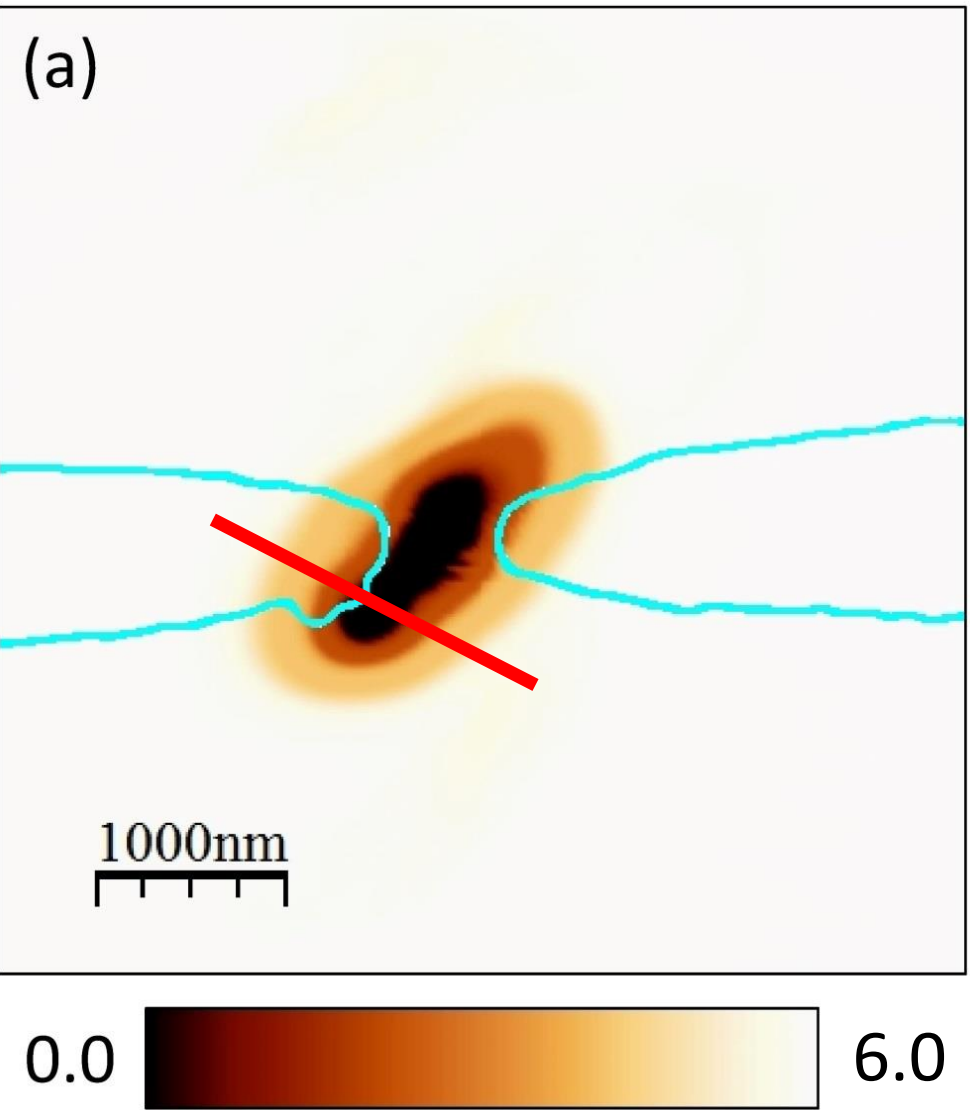


In 1D systems the current is carried by a finite number of modes (arising from confined subbands) . Each mode contributes two quantum of conductance.

First we fix the mode number (QPC setpoint), then we start scanning the biased tip at a fixed height.

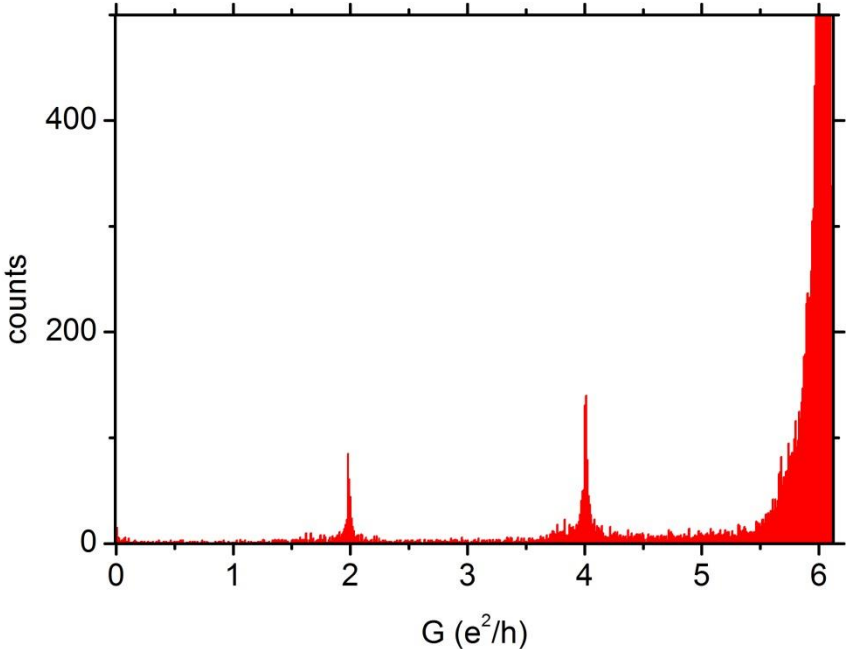
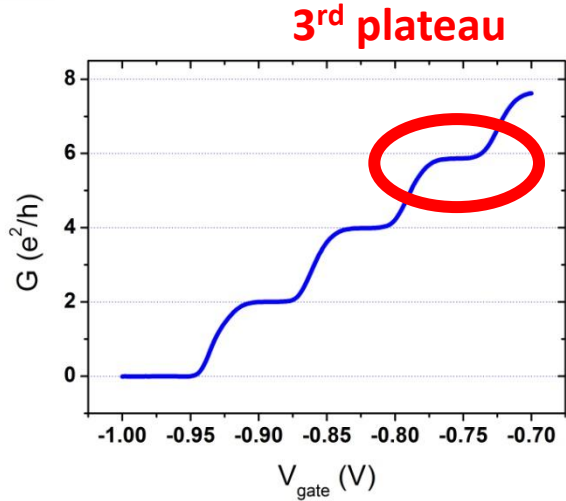
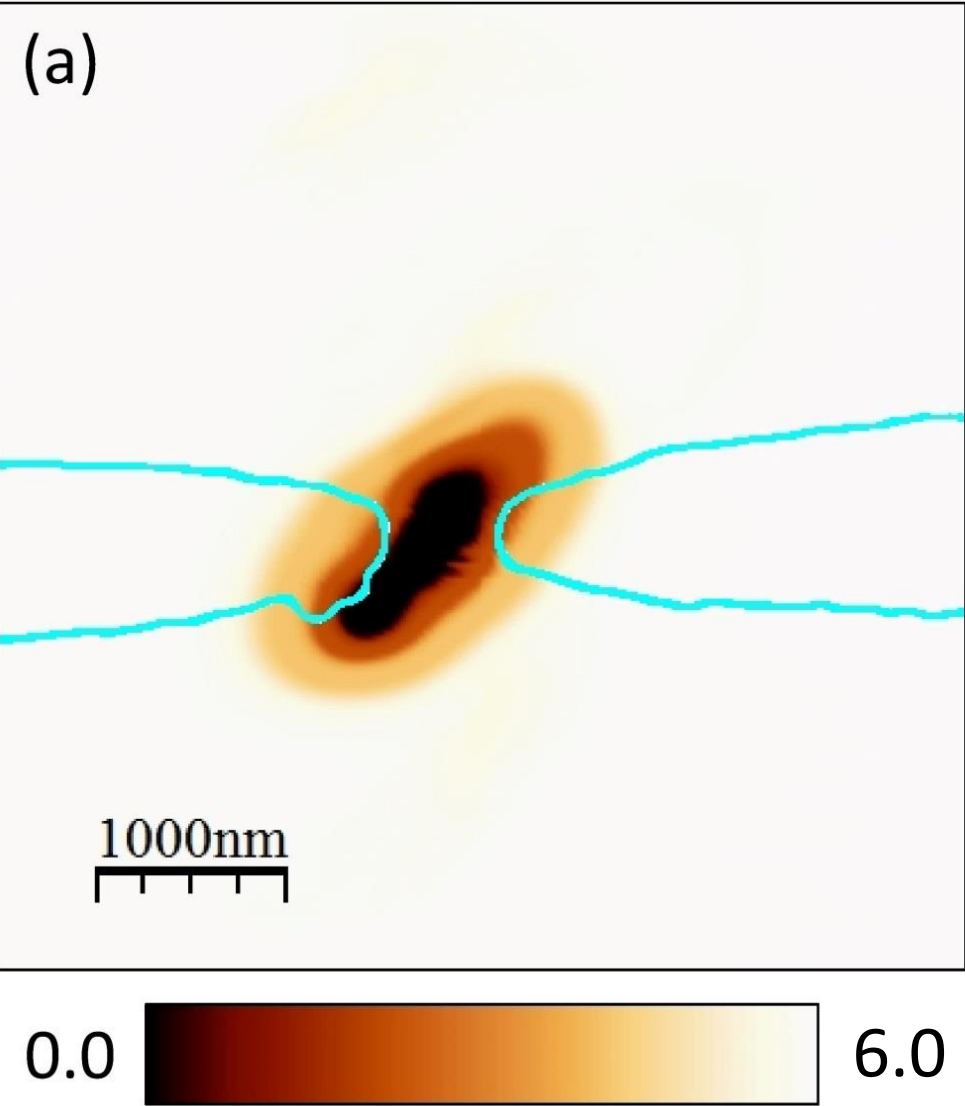


# QPC at 3rd plateau

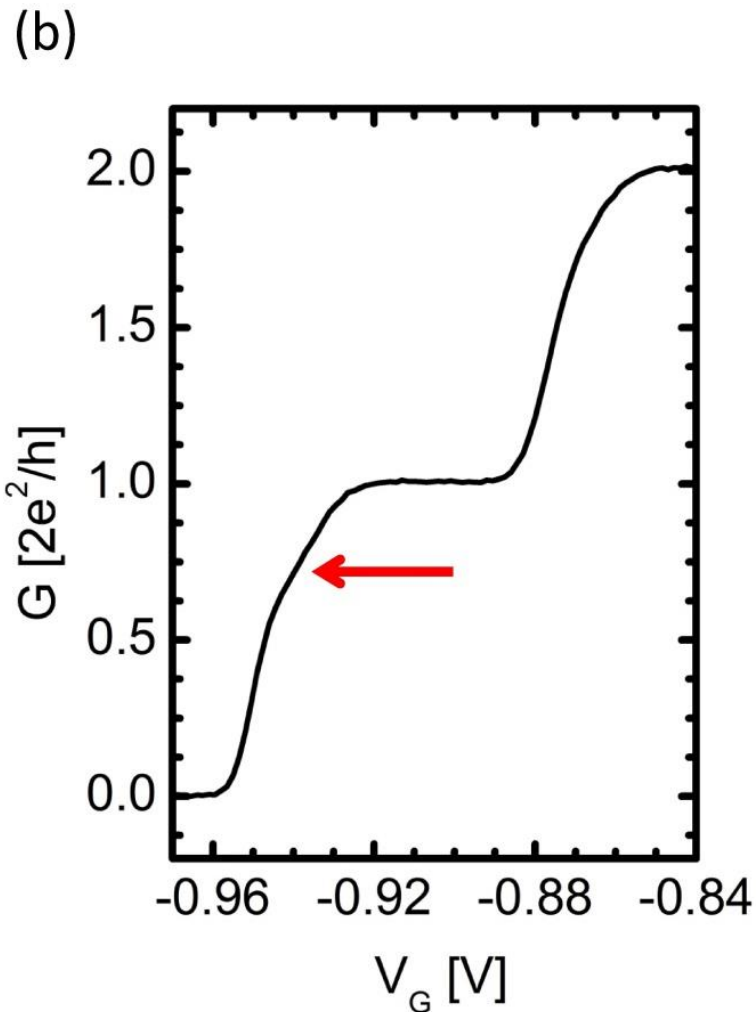




# Histogram analysis



# 0.7 Anomaly



Origin still debated  
Intrinsic or extrinsic?

- Quantum interference
- Spin polarization
- Kondo effect
- Wigner crystallization

A. Iqbal *et al.*, *Nano Research* 8, 948 (2015).

# 0.7 Anomaly

## LETTER

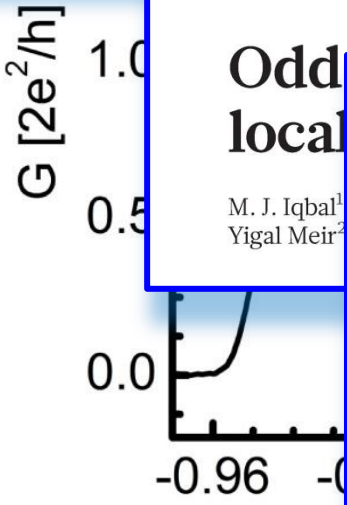
doi:10.1038/nature12421

### Microscopic origin of the '0.7-anomaly' in quantum point contact

Florian Bauer<sup>1</sup>  
Werner Wegscheider<sup>1</sup>

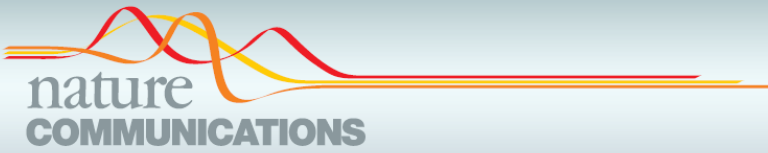
## LETTER

doi:10.1038/nature12491



### Odd local

M. J. Iqbal<sup>1</sup>  
Yigal Meir<sup>2</sup>



### ARTICLE

Received 27 Nov 2013 | Accepted 4 Jun 2014 | Published 30 Jun 2014

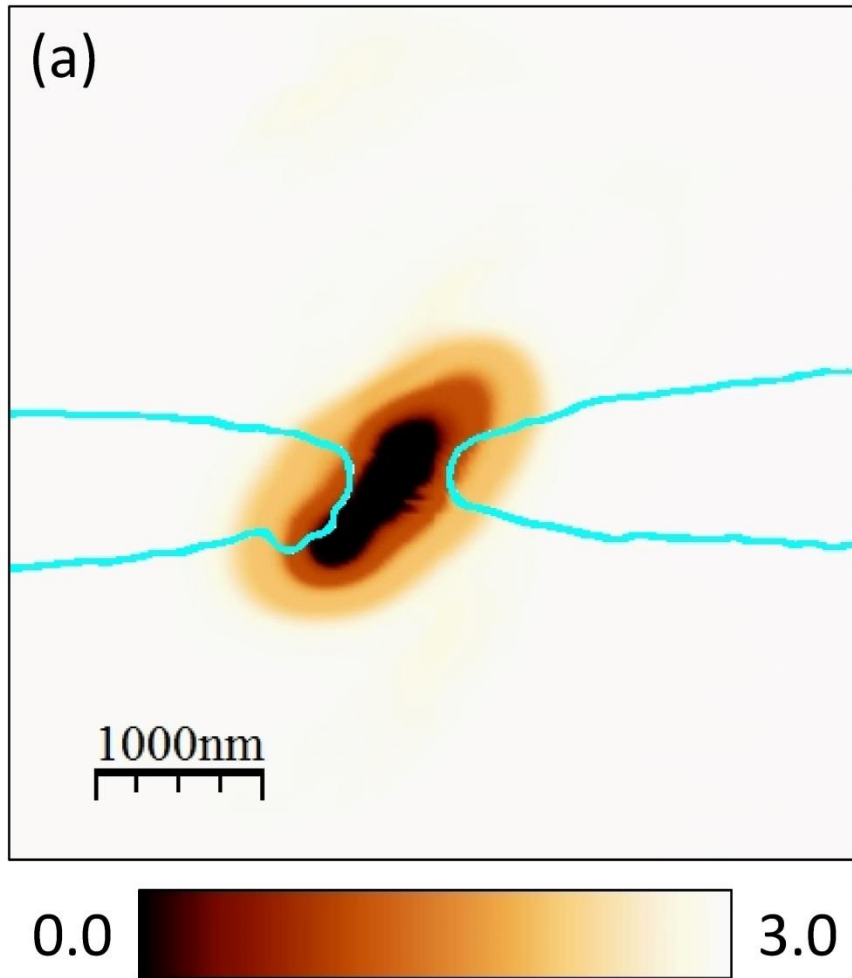
DOI: 10.1038/ncomms5290

### Wigner and Kondo physics in quantum point contacts revealed by scanning gate microscopy

B. Brun<sup>1,2</sup>, F. Martins<sup>3</sup>, S. Faniel<sup>3</sup>, B. Hackens<sup>3</sup>, G. Bachelier<sup>1,2</sup>, A. Cavanna<sup>4</sup>, C. Ulysse<sup>4</sup>, A. Ouerghi<sup>4</sup>, U. Gennser<sup>4</sup>, D. Mailly<sup>4</sup>, S. Huant<sup>1,2</sup>, V. Bayot<sup>1,3</sup>, M. Sanquer<sup>1,5</sup> & H. Sellier<sup>1,2</sup>

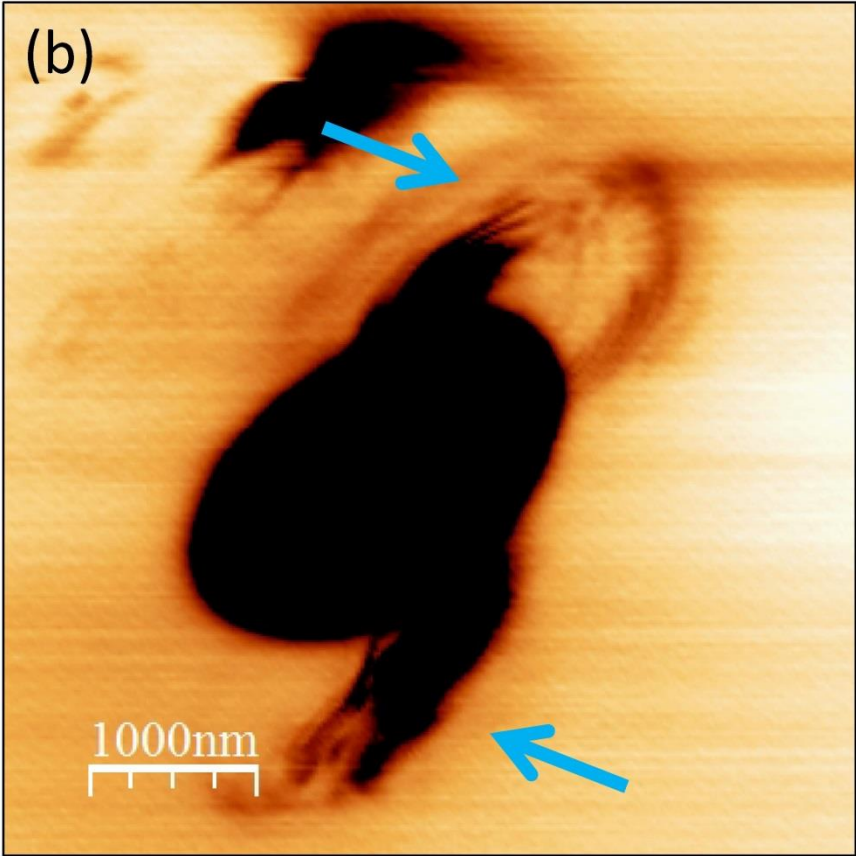
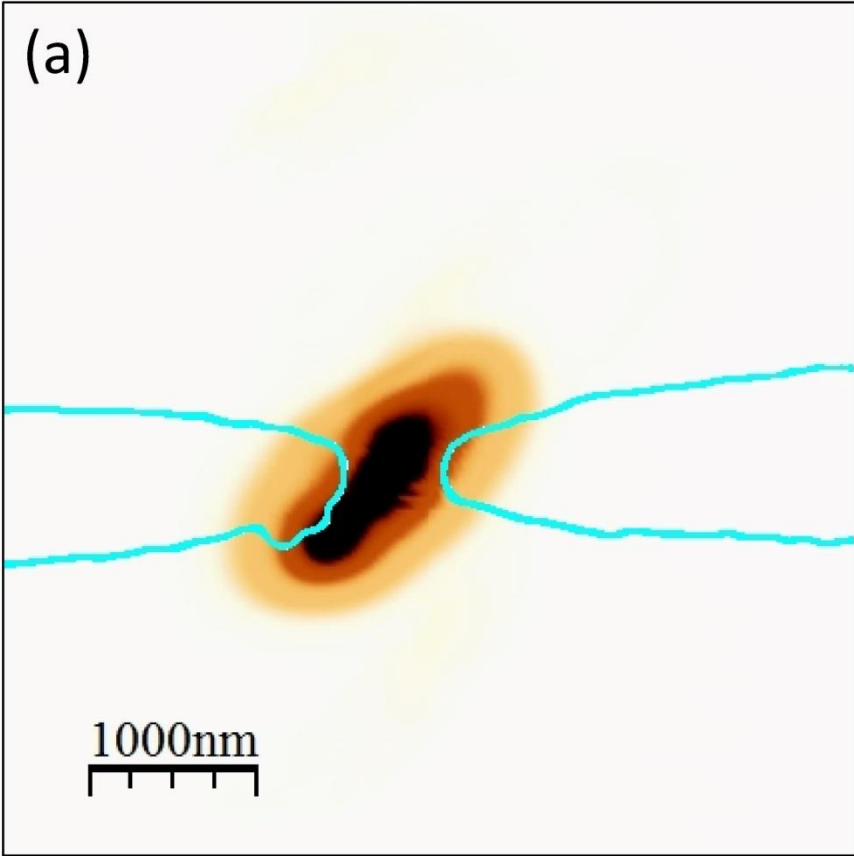
A. Iqbal *et al.*, *Nano F...*

# Device A: QPC with localized impurities



A. Iagallo *et al.*, *Nano Research* 8, 948 (2015).

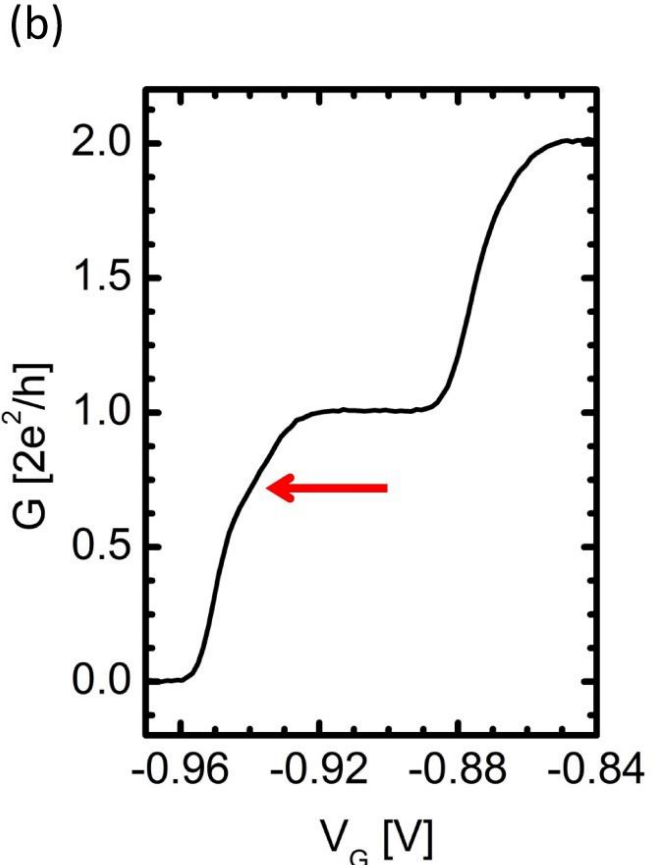
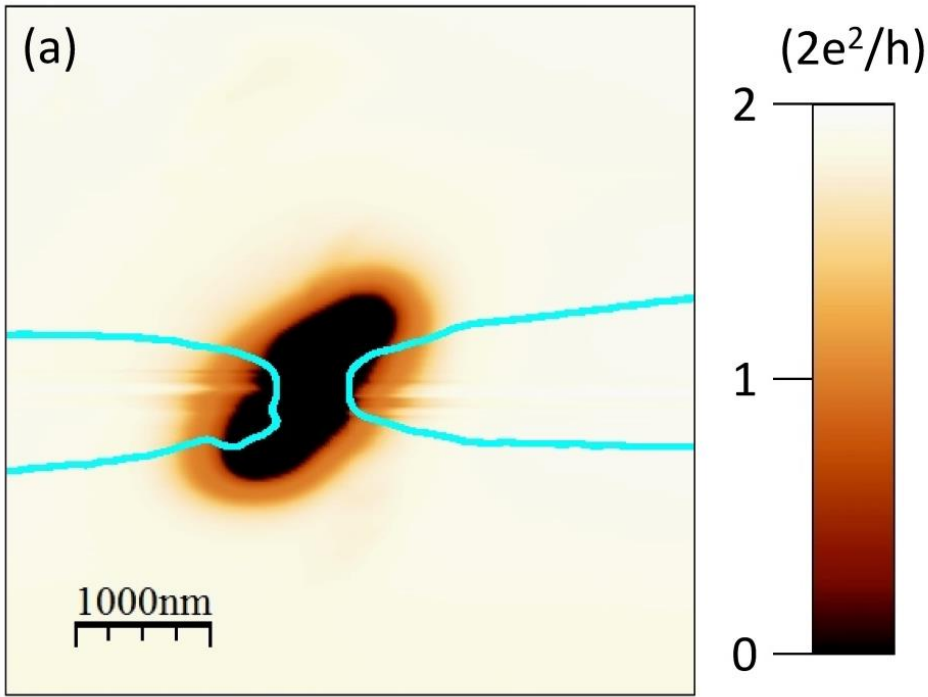
# Device A: QPC with localized impurities



A. Iagallo *et al.*, Nano Research 8, 948 (2015).

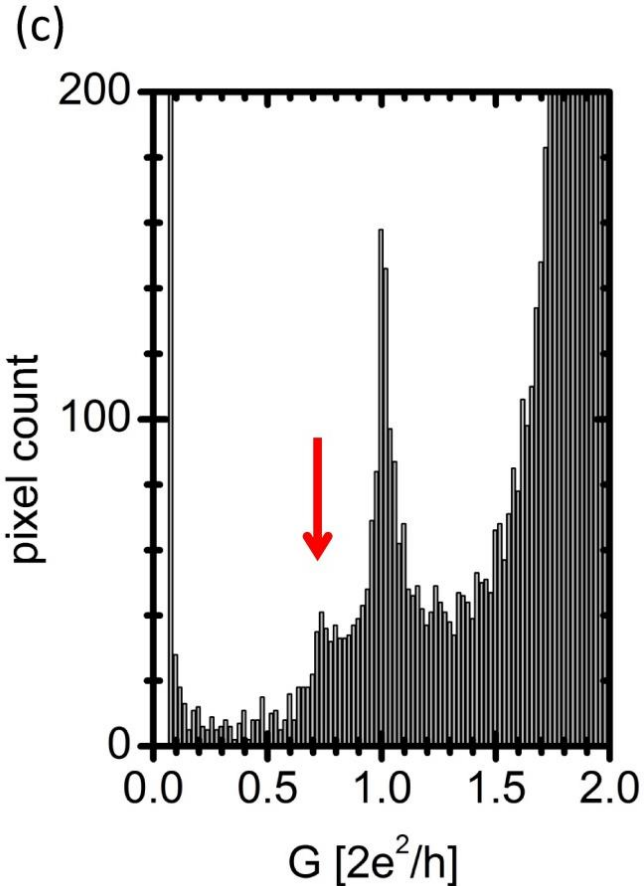
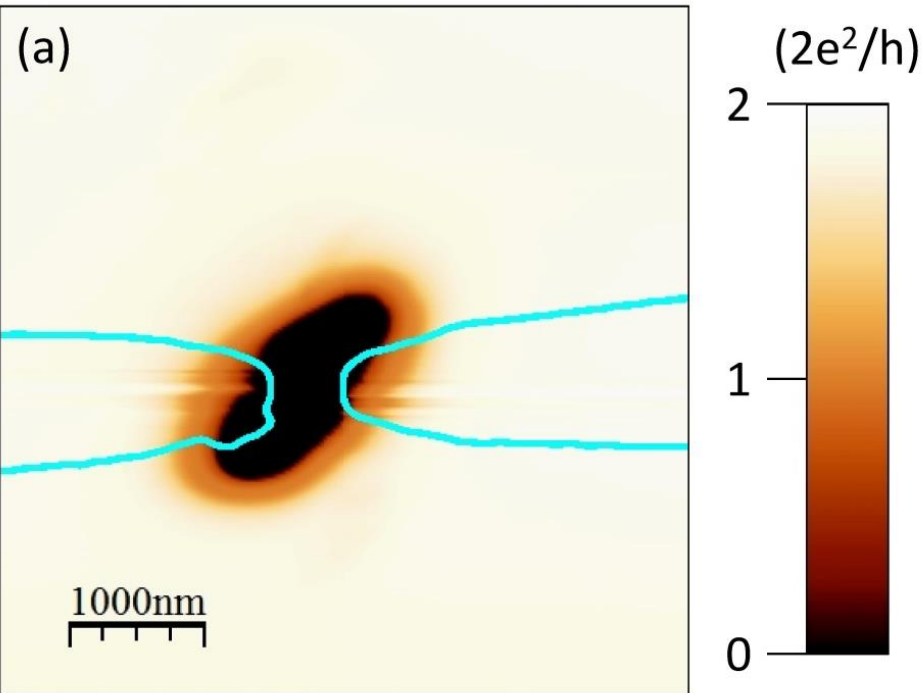


# 0.7 Anomaly in Device A



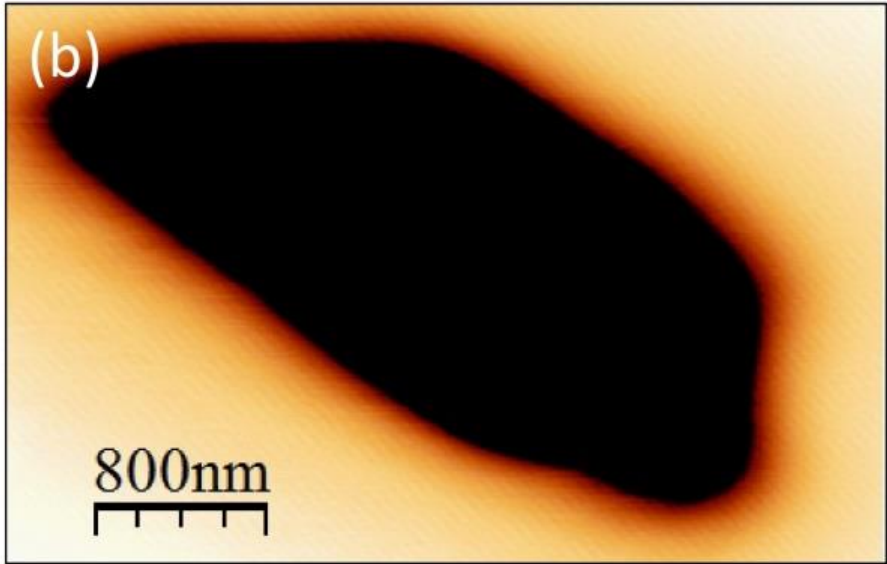
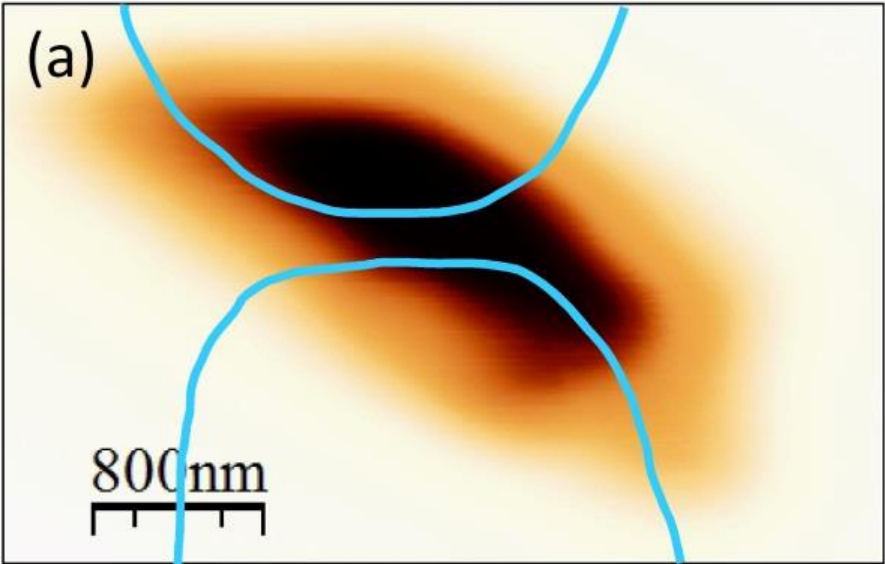
A. Iqbal *et al.*, Nano Research 8, 948 (2015).

# 0.7 Anomaly in Device A



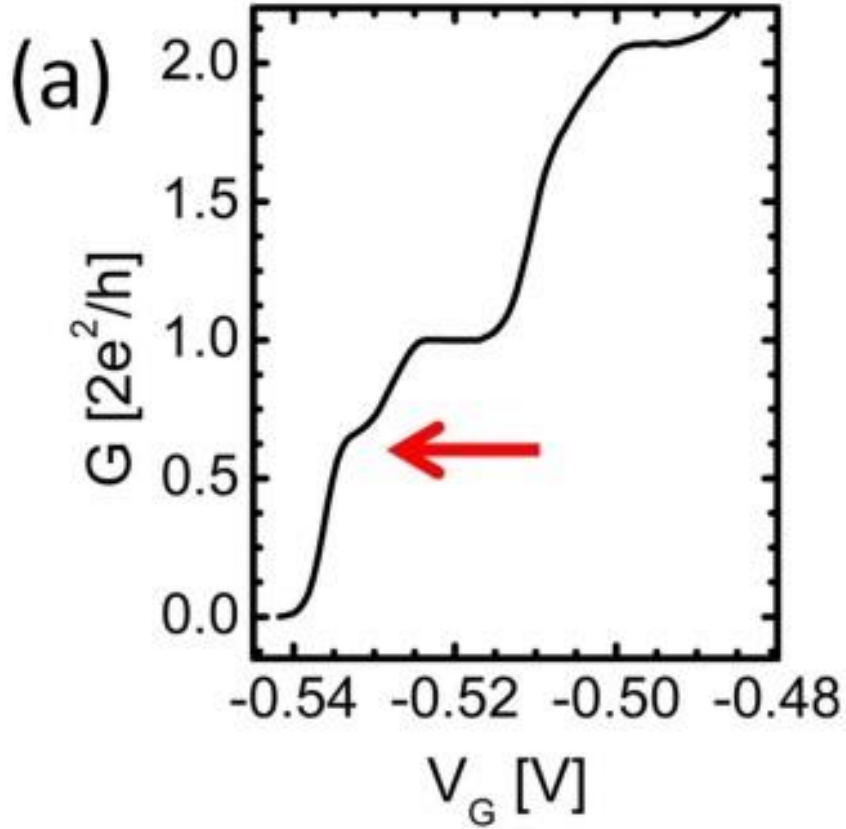
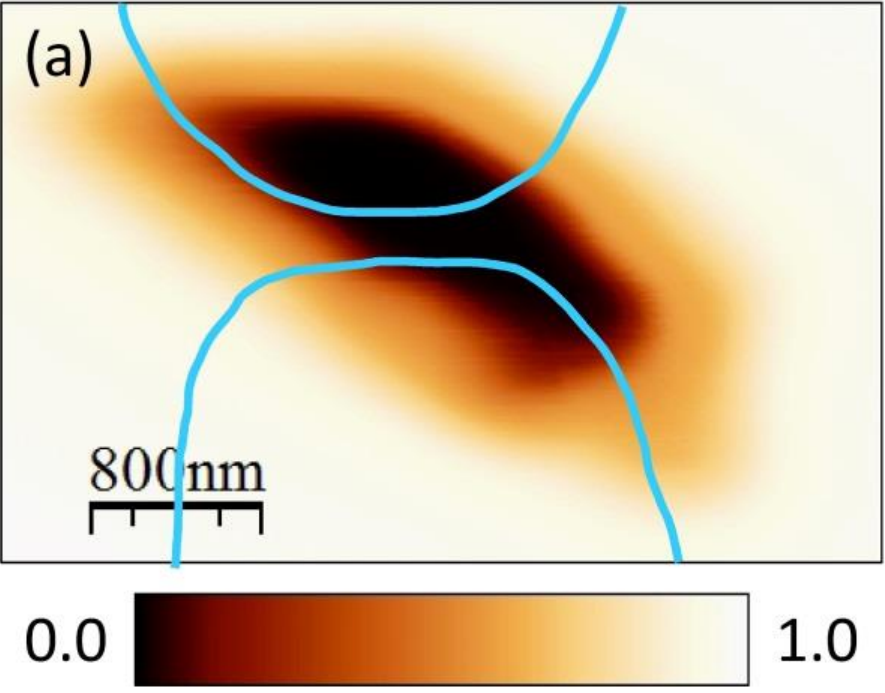
A. Iqbal *et al.*, Nano Research 8, 948 (2015).

# Device B: QPC without localized impurities



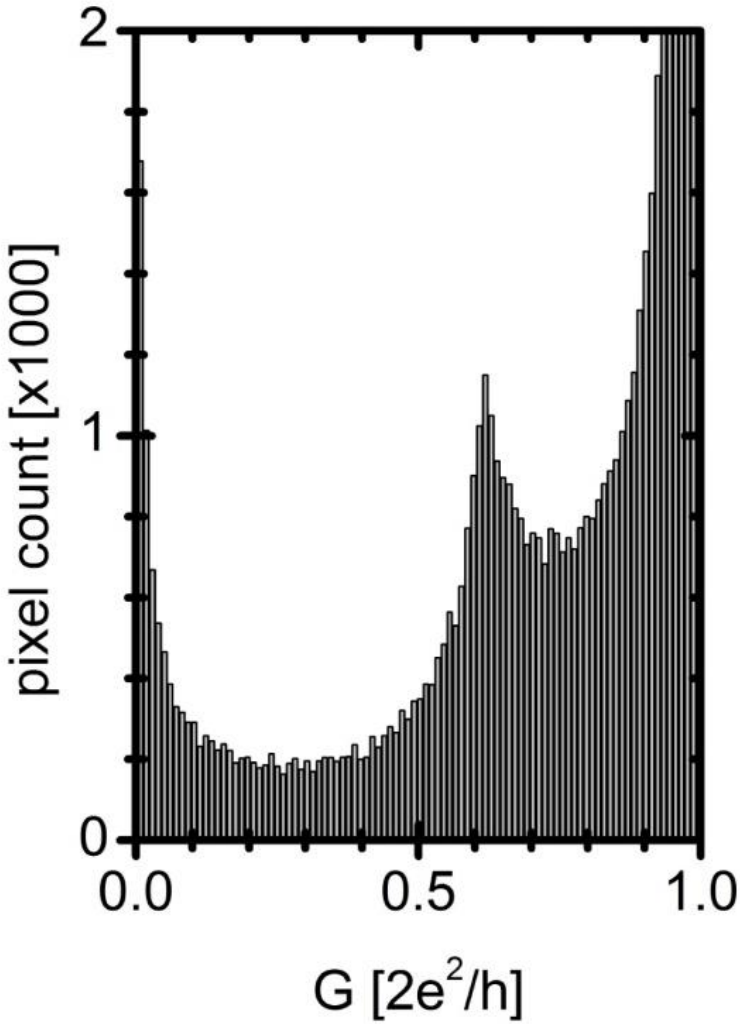
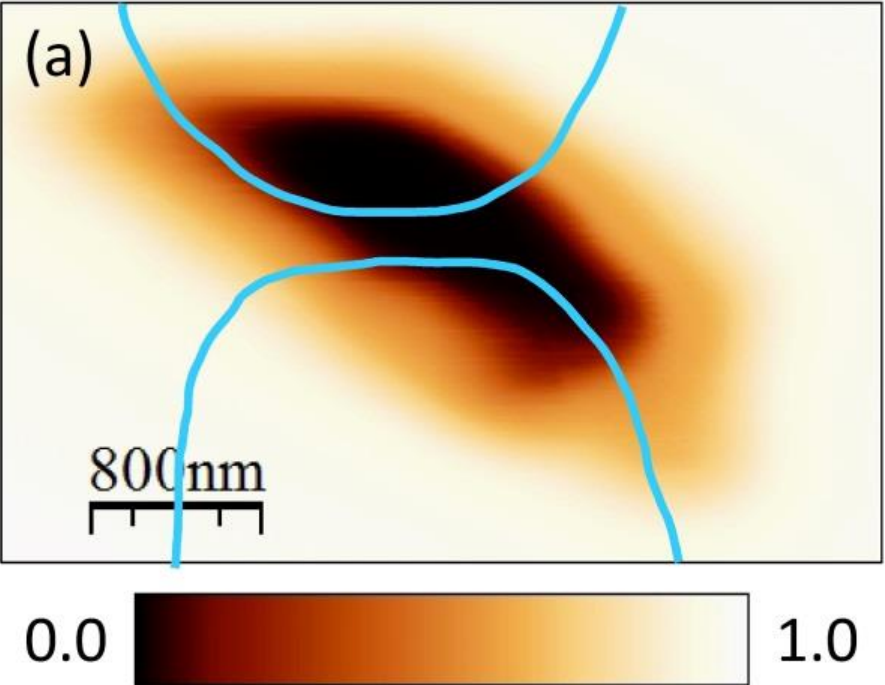
A. Iagallo *et al.*, Nano Research 8, 948 (2015).

# 0.7 Anomaly in Device B



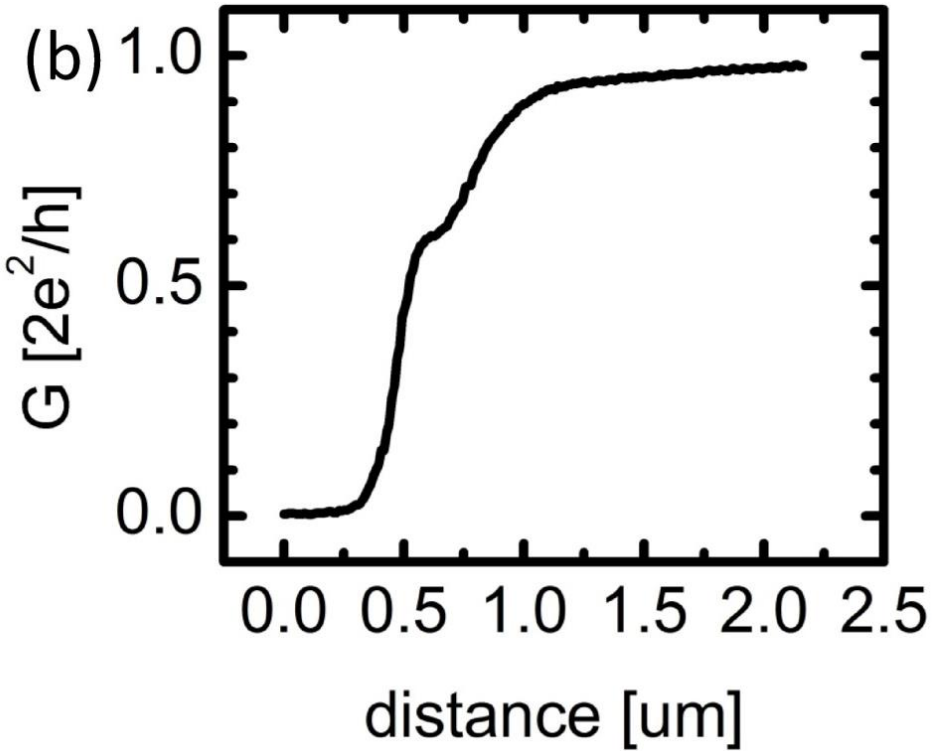
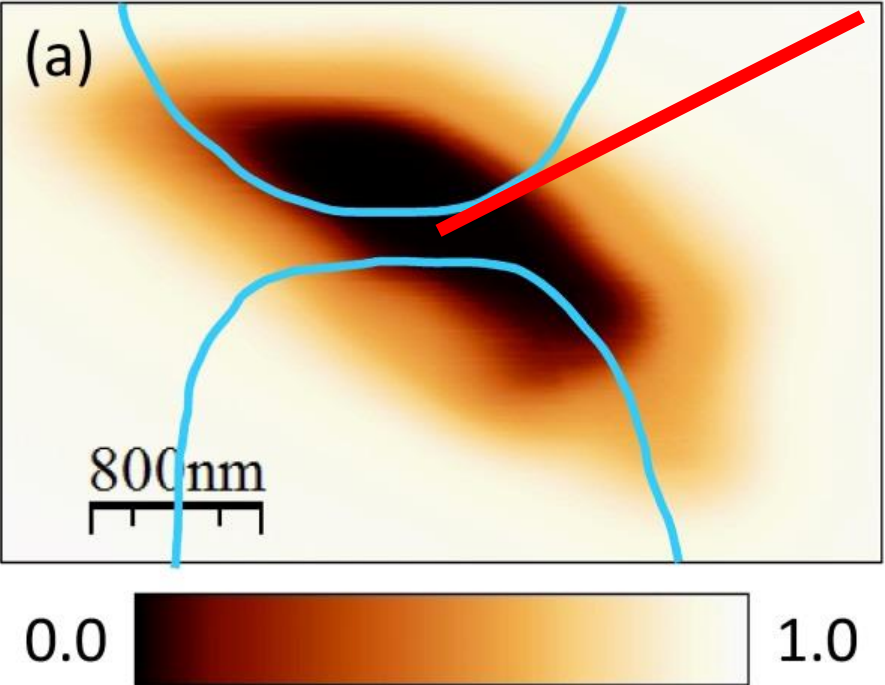
A. Iqbal *et al.*, Nano Research 8, 948 (2015).

# 0.7 Anomaly in Device B



A. Iqbal *et al.*, Nano Research 8, 948 (2015).

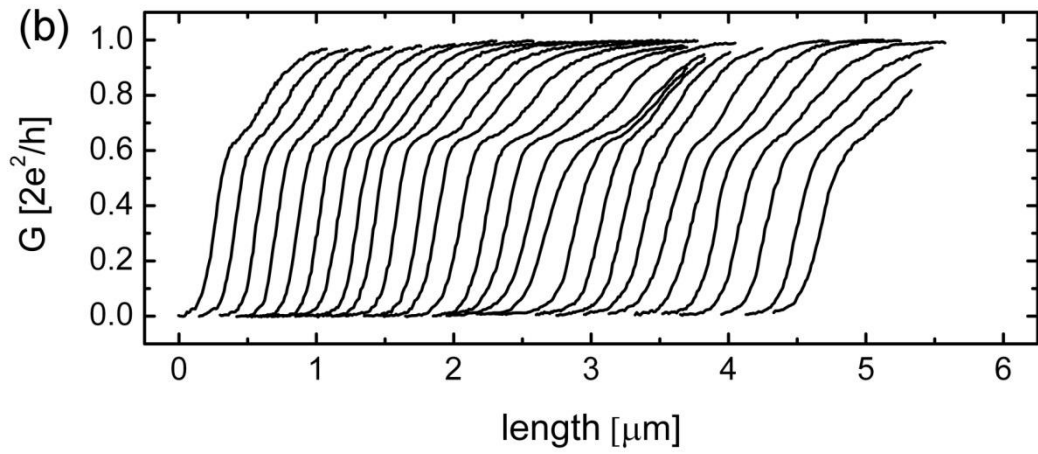
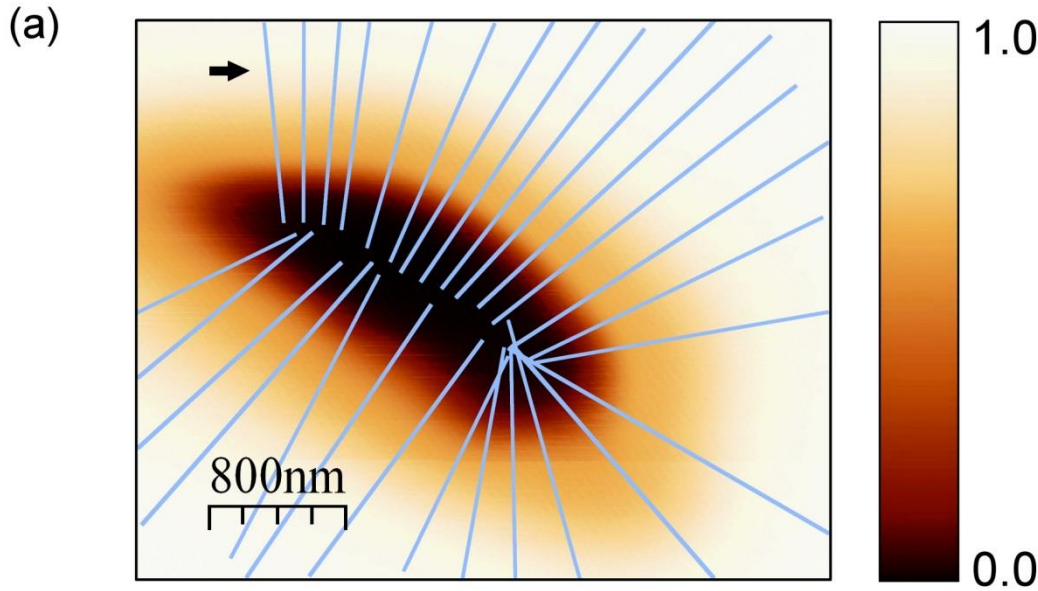
# 0.7 Anomaly in Device B



A. Iagallo *et al.*, Nano Research 8, 948 (2015).

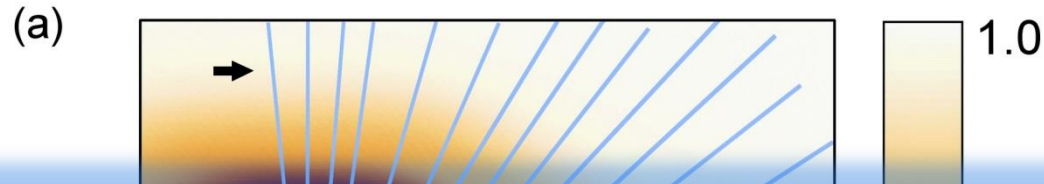


# 0.7 Anomaly in Device B

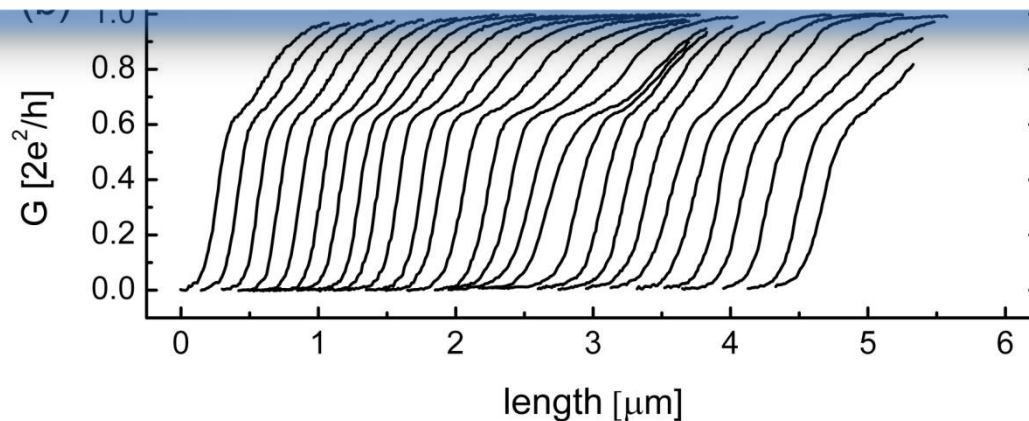


**A. Iagallo *et al.*,  
Nano Research 8, 948 (2015).**

# 0.7 Anomaly in Device B



**The 0.7 anomaly is observed irrespective of the presence of localized defects and is therefore a fundamental property.**



**A. Iqbal *et al.*,  
Nano Research 8, 948 (2015).**

- **Basics of Scanning Gate Microscopy (SGM)**
- **0.7 Anomaly in a Quantum Point Contact**
- **Ongoing Activities**
  - **Graphene Nanoribbons**
  - **Split Gates in Graphene**
  - **Phosphorene**
  - **Hybrid (S-N-S) Systems**





Alina Mrenca-Kolasinska

# PHYSICAL REVIEW B

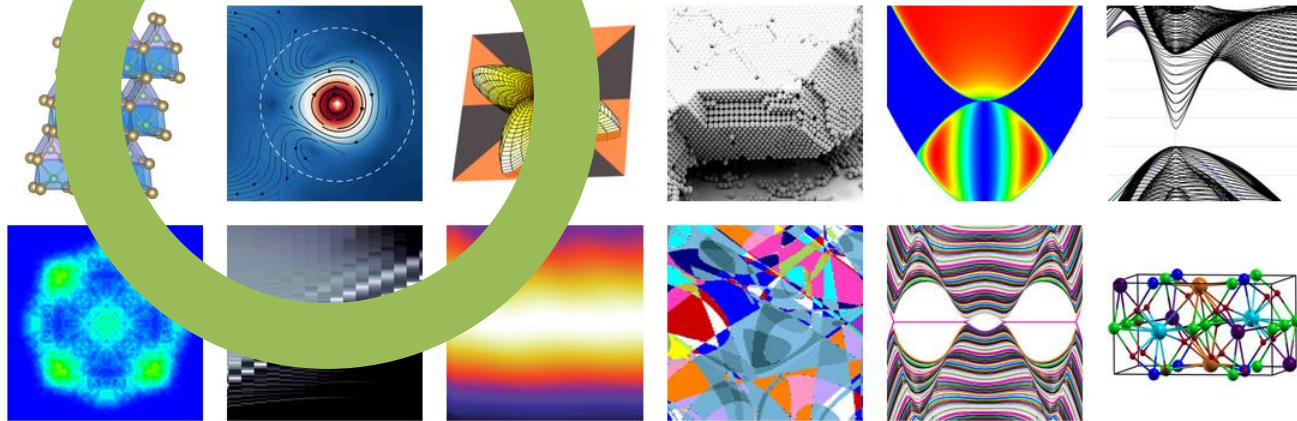
covering condensed matter and materials physics

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## Kaleidoscope March 2016

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# Aharonov-Bohm interferometer based on *n-p* junctions in graphene nanoribbons

A. Mreńca-Kolasińska,<sup>1,2,\*</sup> S. Heun,<sup>2</sup> and B. Szafran<sup>1</sup>

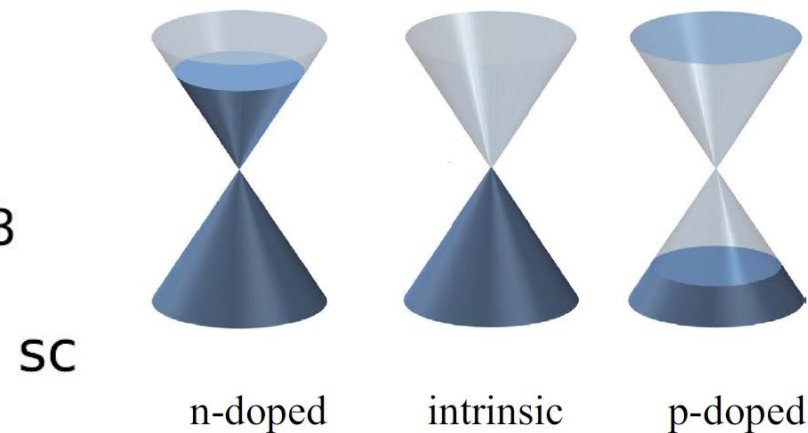
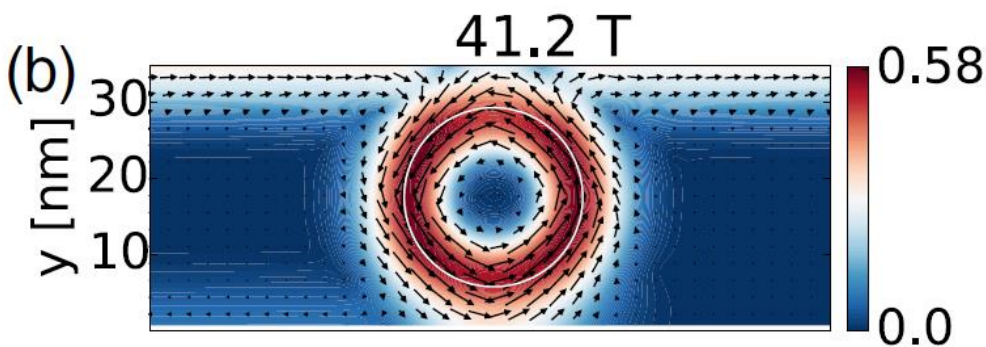
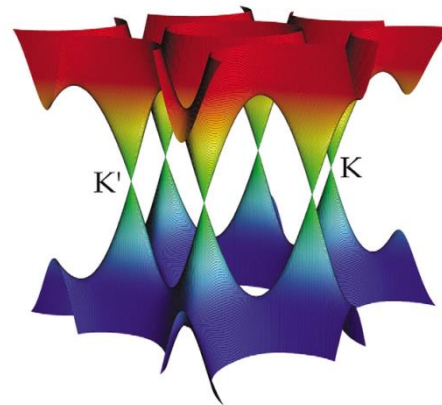
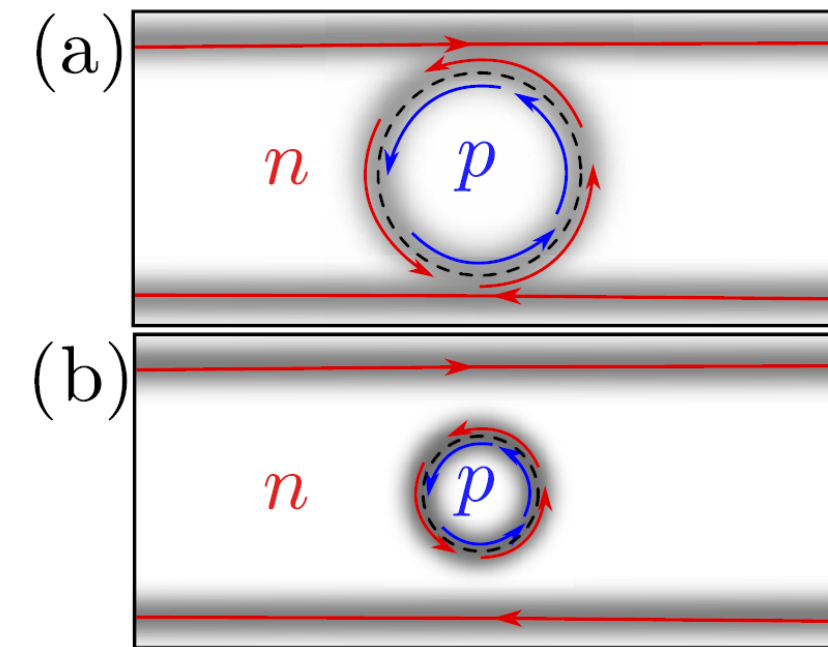
<sup>1</sup>AGH University of Science and Technology, Faculty of Physics and Applied Computer Science, al. Mickiewicza 30, 30-059 Kraków, Poland

<sup>2</sup>NEST, Istituto Nanoscienze-CNR and Scuola Normale Superiore, Piazza San Silvestro 12, 56127 Pisa, Italy

(Received 12 November 2015; revised manuscript received 28 January 2016; published 8 March 2016)



Alina Mreńca-Kolasińska





# Ribbon design



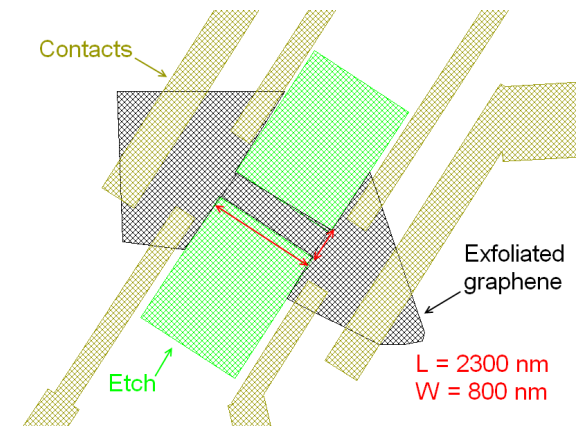
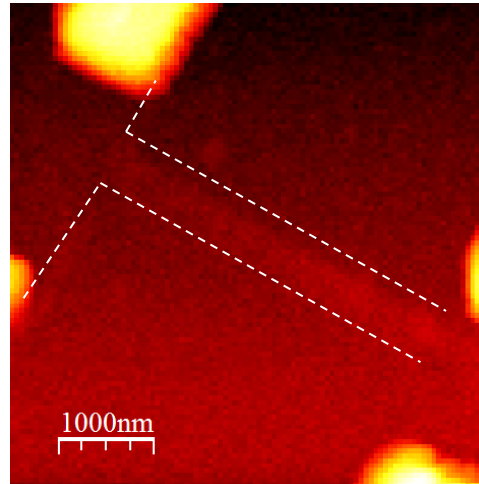
Lennart Bours

1. Scanning Electron Microscope picture of the heavily damaged C9 device
2. AFM scan of the G4 device (used for SGM)
3. Design of the G4 device

C9: 5000 x 900 nm



G4: 2300 x 800 nm

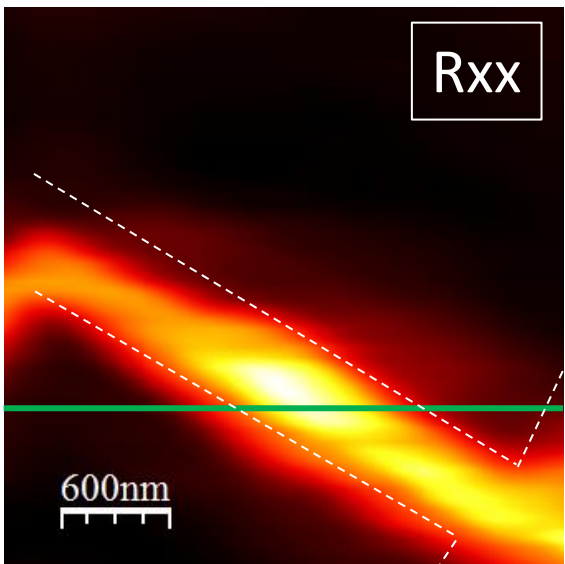




# G4



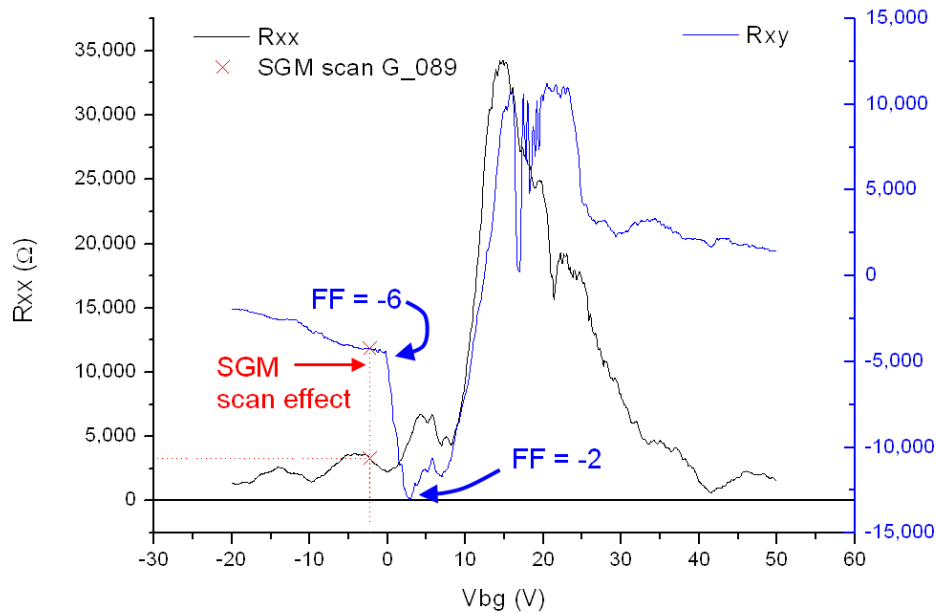
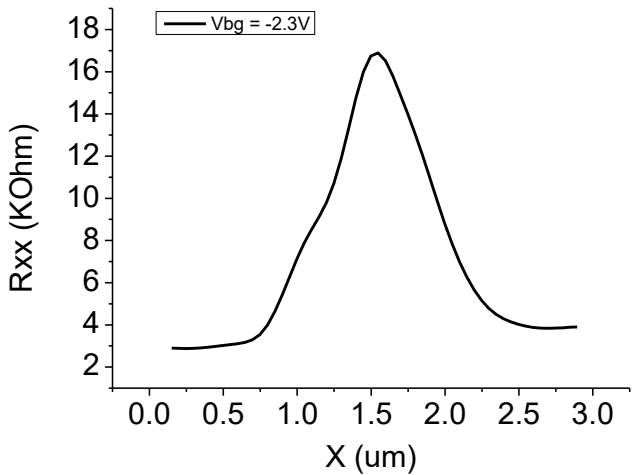
Lennart Bours



SGM scan:

$V_{bg} = -2.3V$ ,  $V_{tip} = 20V$ ,  $d = 26nm$ ,  
 $B = 8T$ ,  $T = 0.42K$

G4: 2300 x 800 nm



## G4

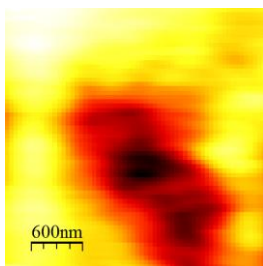
SGM scan:  $V_{bg} = -4.2V$ ,  $V_{tip} = 20V$ ,  $d = 26nm$ ,  $B = 8T$ ,  $T = 0.42K$



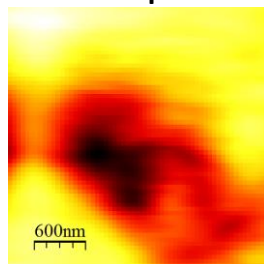
Lennart Bours

- At low tip bias the ribbon shows inhomogeneity
- With increasing bias the ribbon becomes better defined

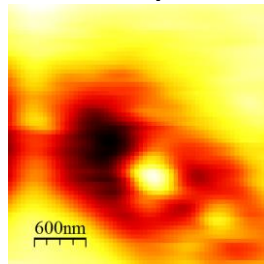
Rxx  $V_{tip} = 0V$



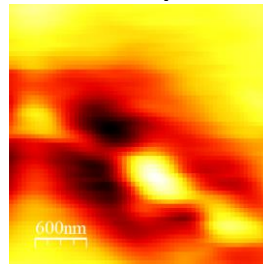
Rxx  $V_{tip} = 1V$



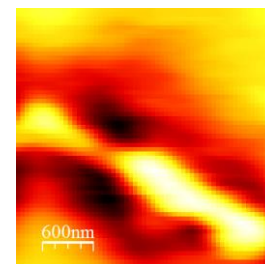
Rxx  $V_{tip} = 3V$



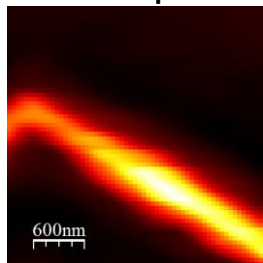
Rxx  $V_{tip} = 4V$



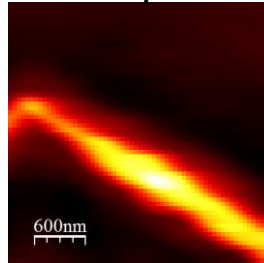
Rxx  $V_{tip} = 5V$



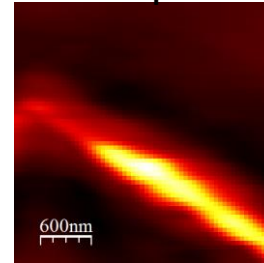
Rxx  $V_{tip} = 20V$



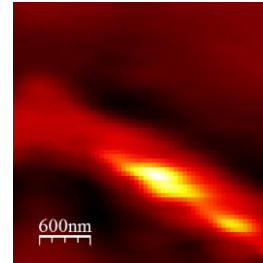
Rxx  $V_{tip} = 15V$



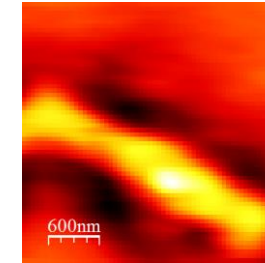
Rxx  $V_{tip} = 12V$



Rxx  $V_{tip} = 10V$



Rxx  $V_{tip} = 7.5V$



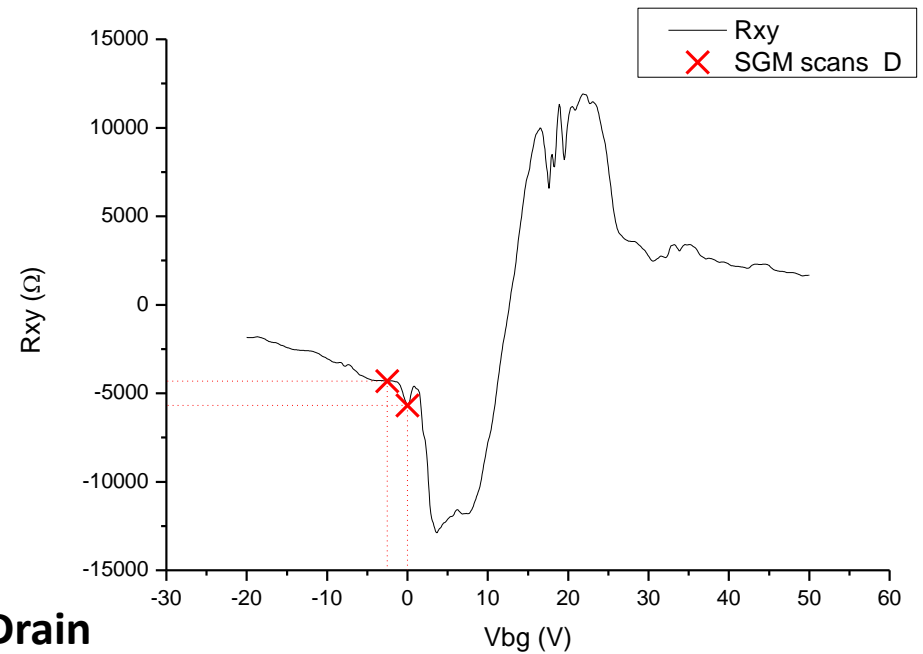
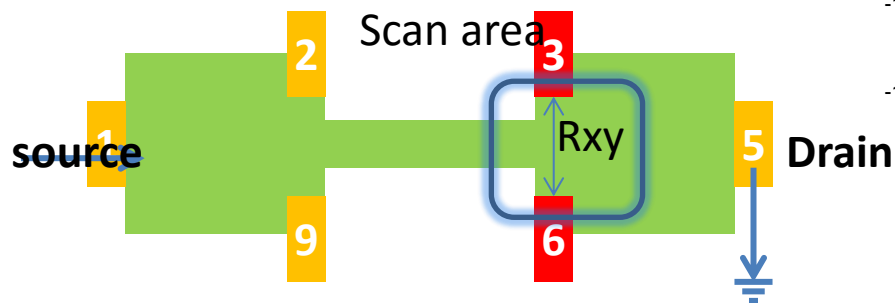
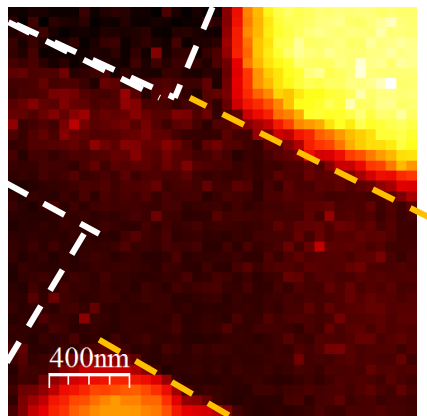
## G4

SGM scan:  $V_{bg} = -4.2V$ ,  $V_{tip} = 20V$ ,  $d = 26nm$ ,  $B = 8T$ ,  $T = 0.42K$



Lennart Bours

- Two series of scans;
- One starting from the filling factor = -6 plateau
- One starting between filling factor = -6 and = -2



# G4

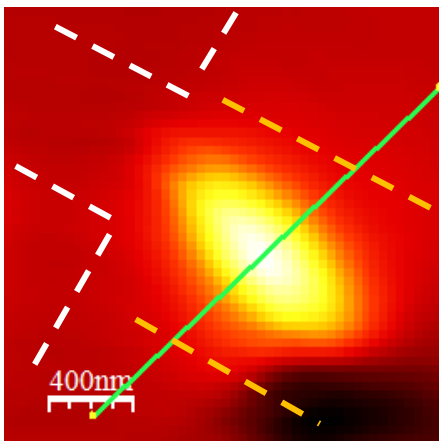
SGM scan:

$V_{bg} = -4.3V$ ,  $B = 8T$ ,  $T = 0.42K$ ,  $d = 104nm$

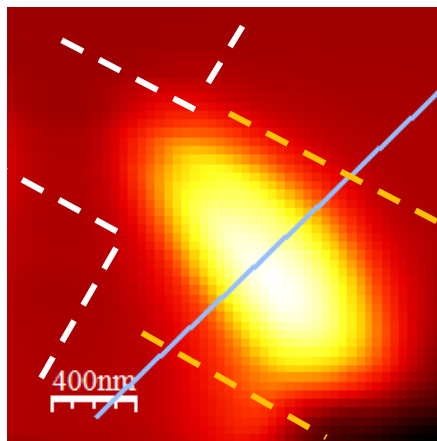


Lennart Bours

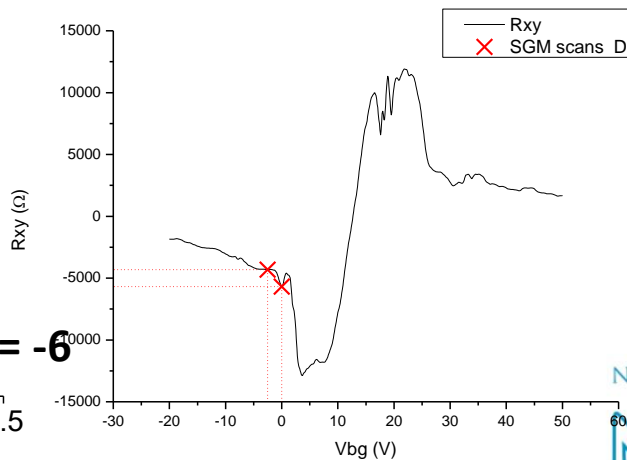
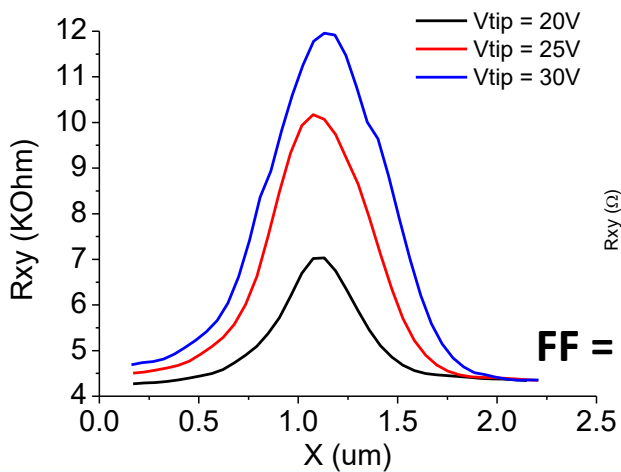
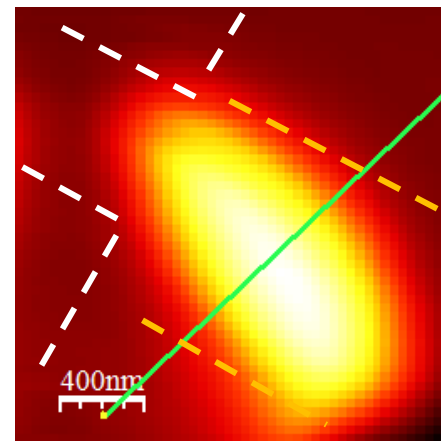
G\_087  $V_{tip} = 20V$



G\_088  $V_{tip} = 25V$



G\_088  $V_{tip} = 30V$



# G4

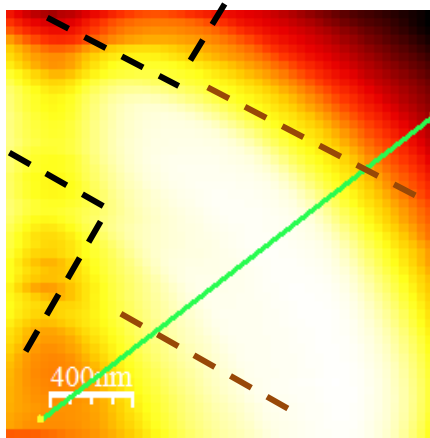
SGM scan:

$V_{bg} = -2.5V$ ,  $B = 8T$ ,  $T = 0.42K$ ,  $d = 104nm$

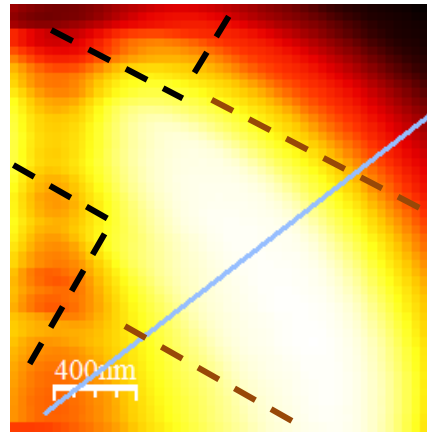


Lennart Bours

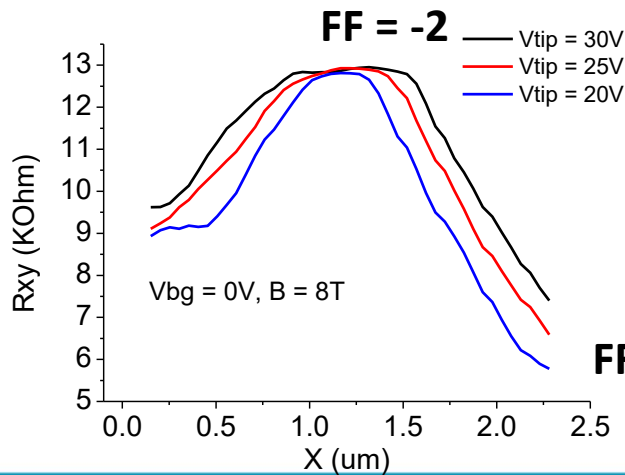
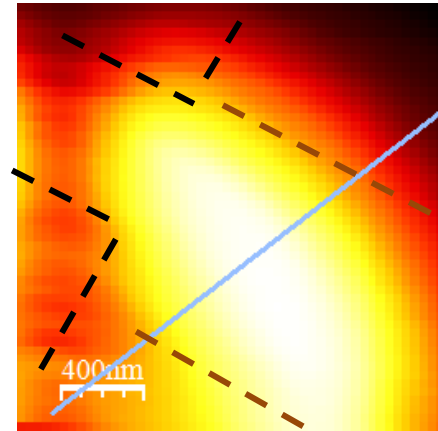
G\_090  $V_{tip} = 30V$



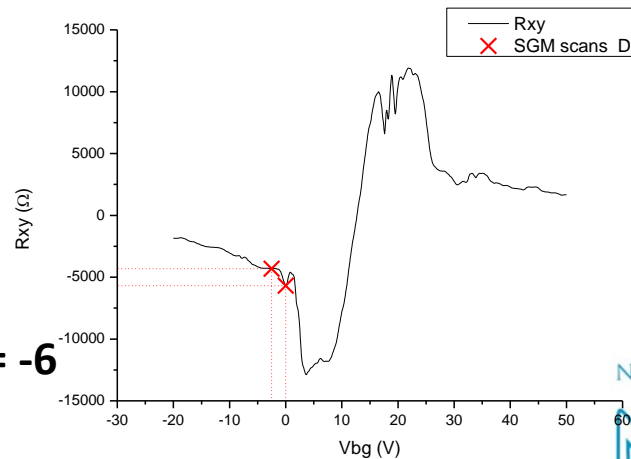
G\_091  $V_{tip} = 25V$



G\_092  $V_{tip} = 20V$

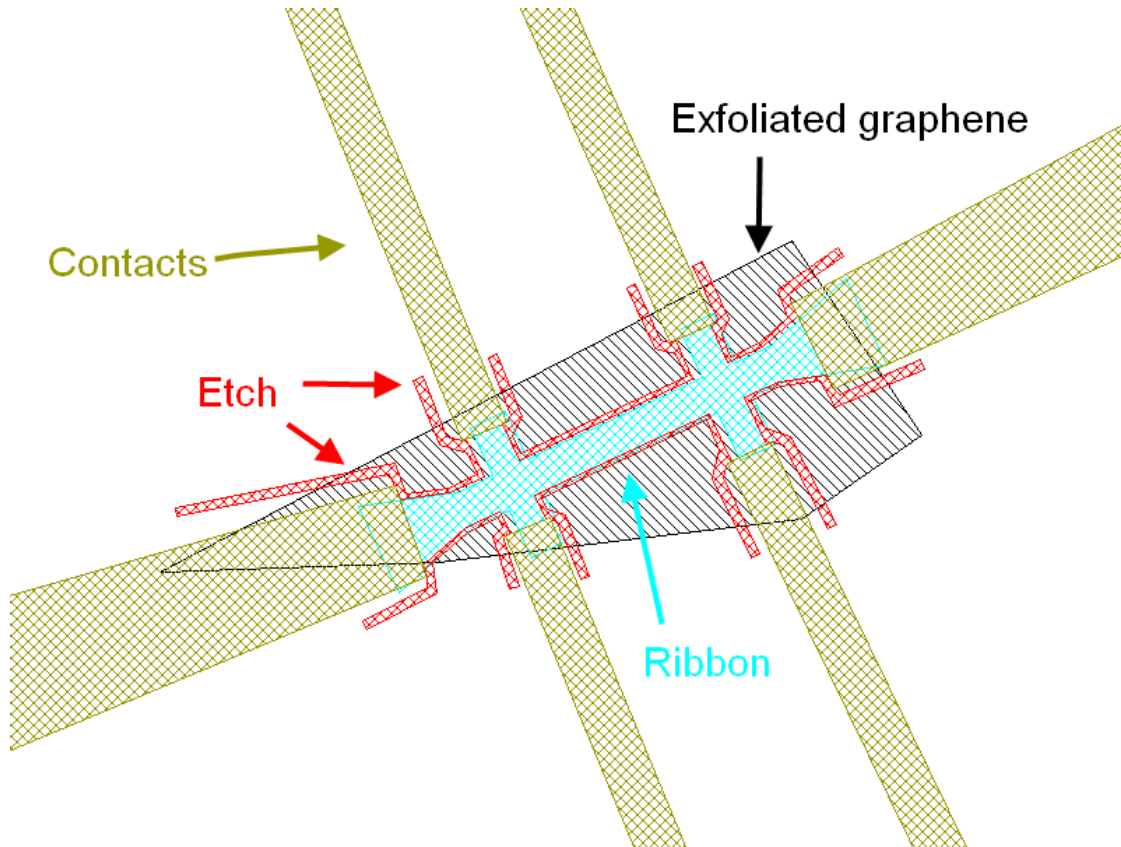


**FF = -6**

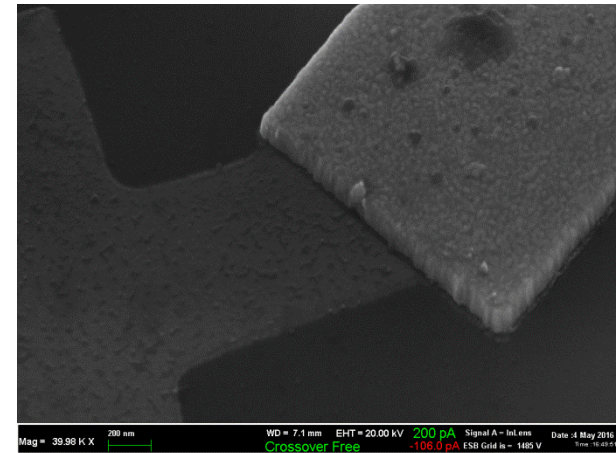
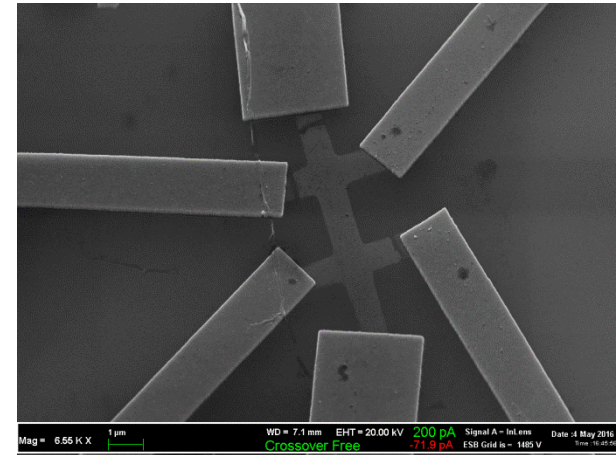


# Outlook

New Design



Lennart Bours





- **Basics of Scanning Gate Microscopy (SGM)**
- **0.7 Anomaly in a Quantum Point Contact**
- **Ongoing Activities**
  - **Graphene Nanoribbons**
  - **Split Gates in Graphene**
  - **Phosphorene**
  - **Hybrid (S-N-S) Systems**



## Gate-Defined Graphene Quantum Point Contact in the Quantum Hall Regime

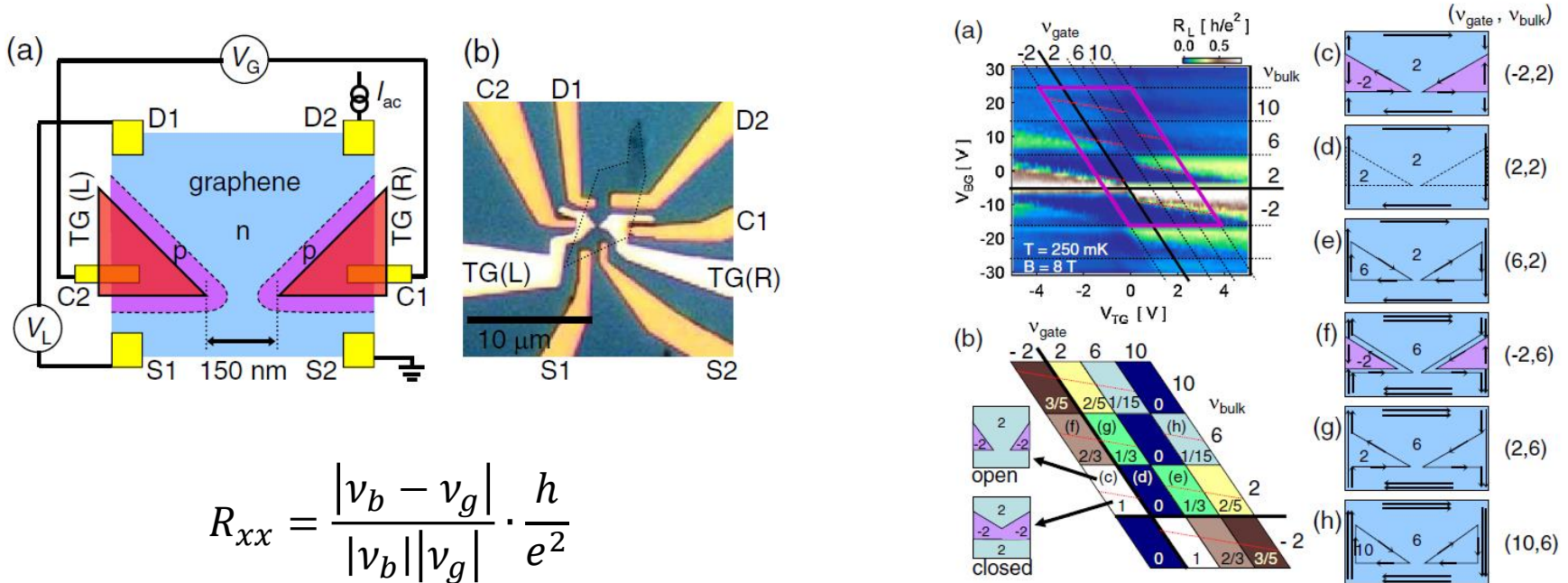
S. Nakaharai,<sup>1,2</sup> J. R. Williams,<sup>1,3,\*</sup> and C. M. Marcus<sup>1</sup>

<sup>1</sup>Department of Physics, Harvard University, Cambridge, Massachusetts 02138, USA

<sup>2</sup>Toshiba Research and Development Center, Kawasaki 212- 8582, Japan

<sup>3</sup>School of Engineering and Applied Sciences, Harvard University, Cambridge, Massachusetts 02138, USA

(Received 11 October 2010; published 14 July 2011)

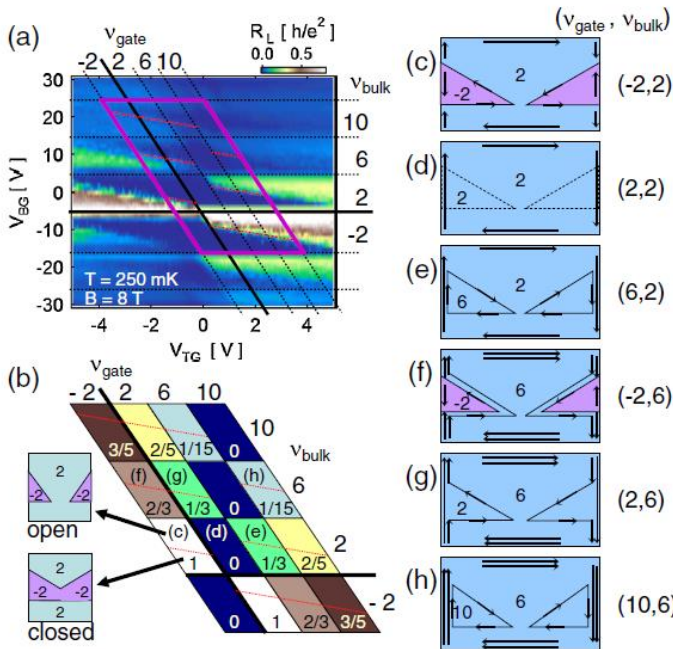
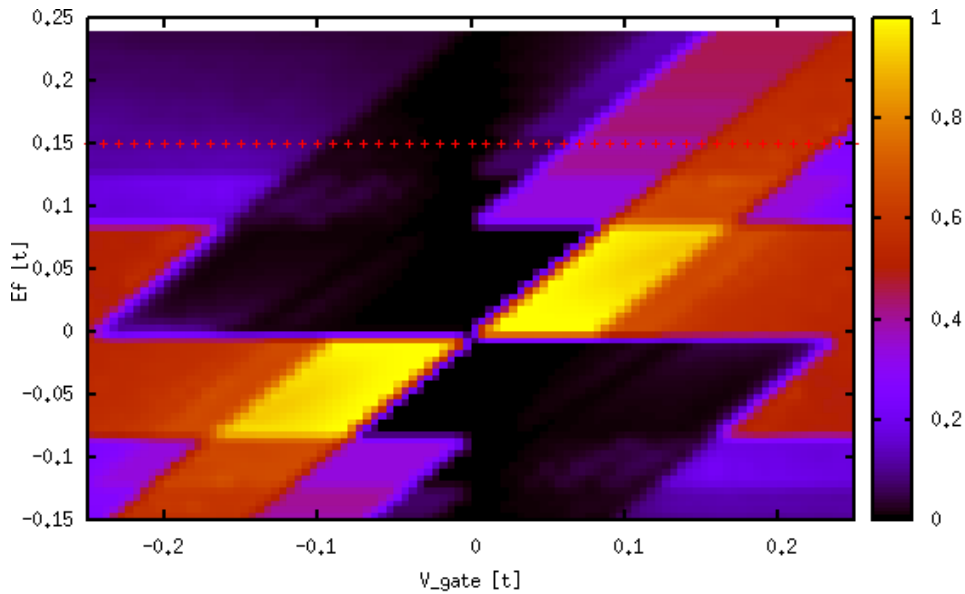


$$R_{xx} = \frac{|v_b - v_g|}{|v_b||v_g|} \cdot \frac{h}{e^2}$$

# Gate-defined QPC in the QH regime



Alina Mrenca-Kolasinska



## Gate-Defined Graphene Quantum Point Contact in the Quantum Hall Regime

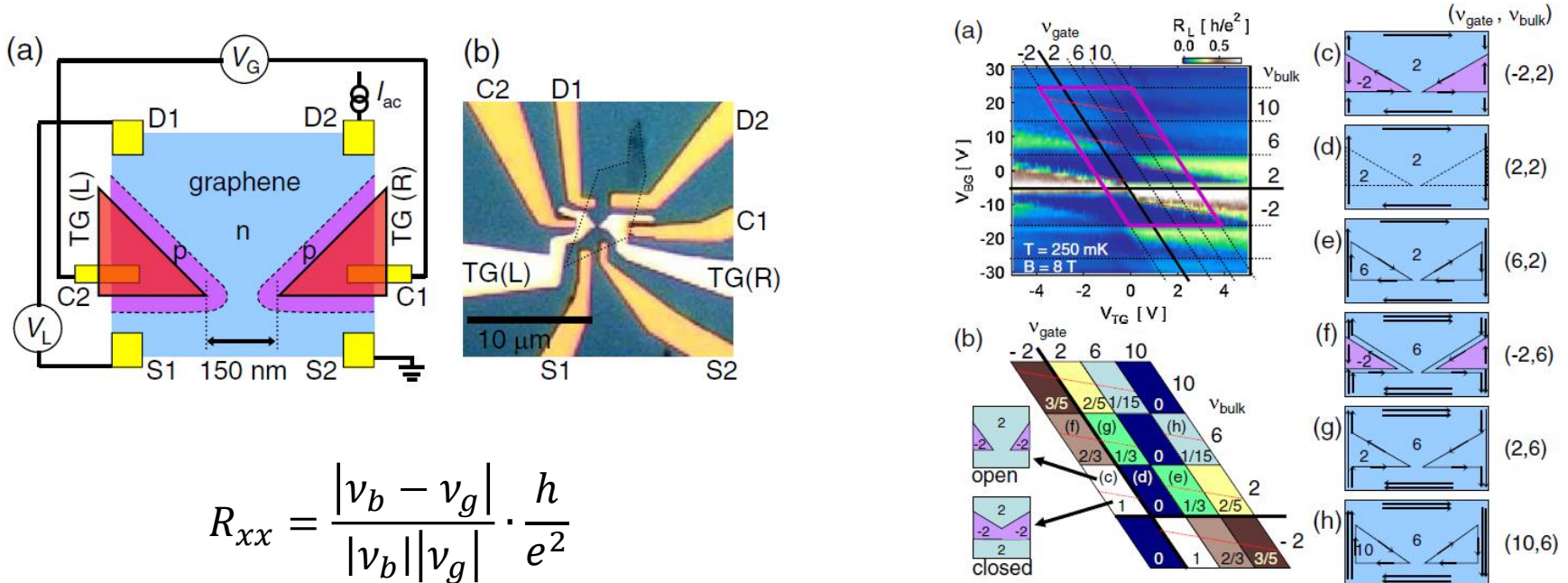
S. Nakaharai,<sup>1,2</sup> J. R. Williams,<sup>1,3,\*</sup> and C. M. Marcus<sup>1</sup>

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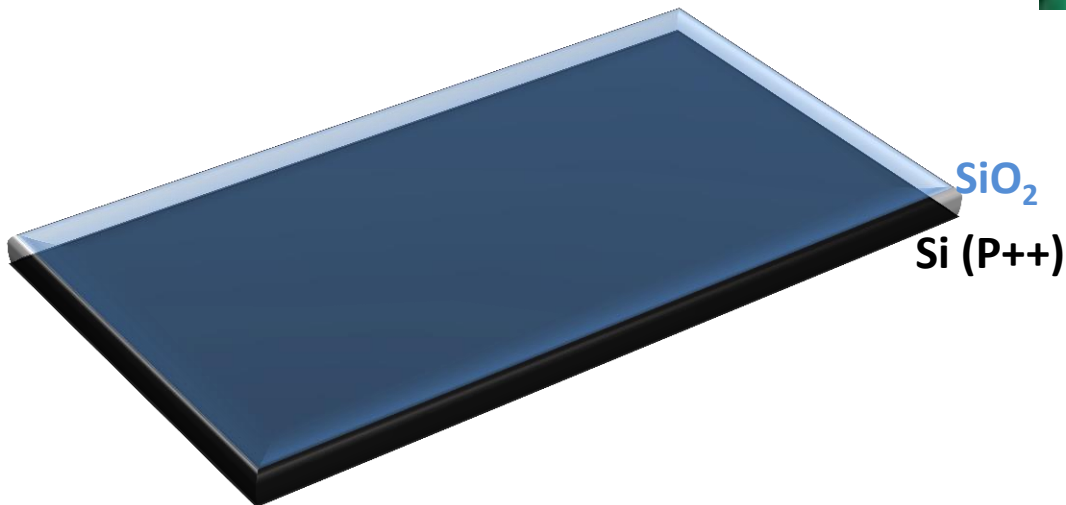


$$R_{xx} = \frac{|v_b - v_g|}{|v_b||v_g|} \cdot \frac{h}{e^2}$$

# Buried split-gate device



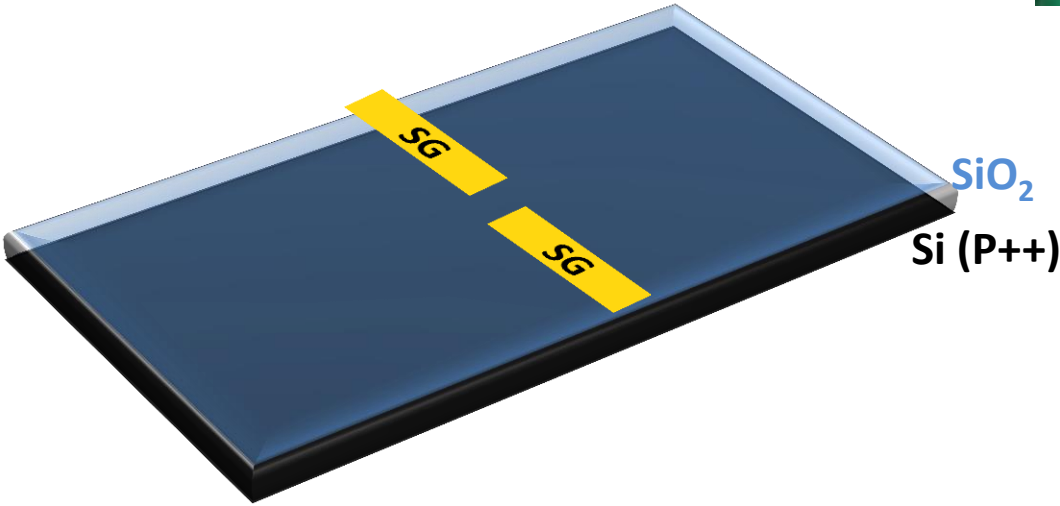
Shaohua Xiang



# Buried split-gate device



Shaohua Xiang

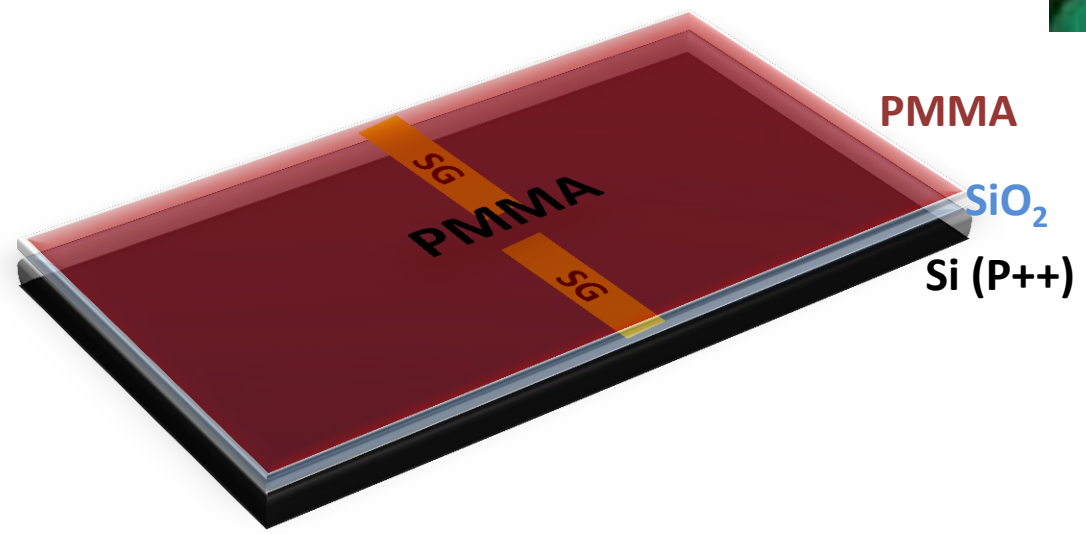




# Buried split-gate device



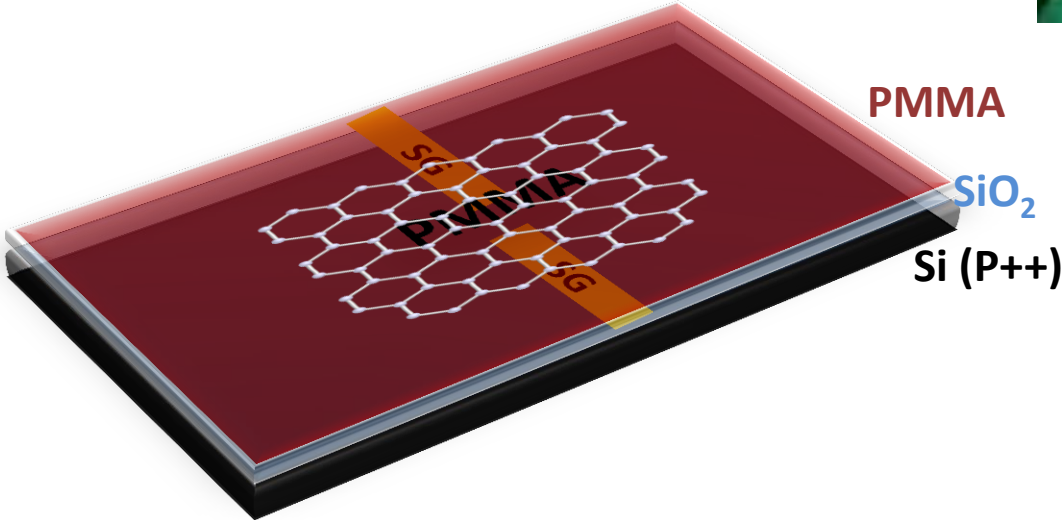
Shaohua Xiang



# Buried split-gate device



Shaohua Xiang



PMMA

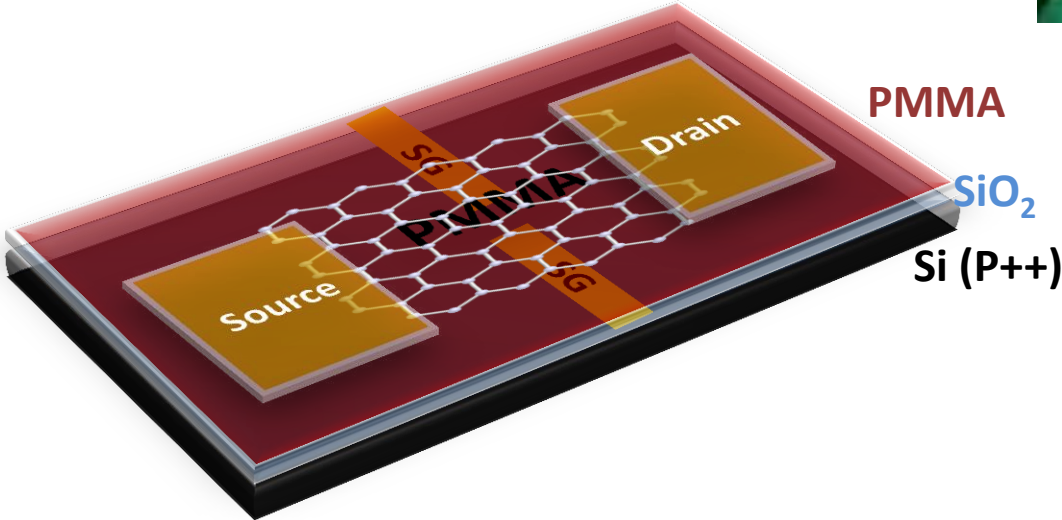
SiO<sub>2</sub>

Si (P++)

# Buried split-gate device



Shaohua Xiang



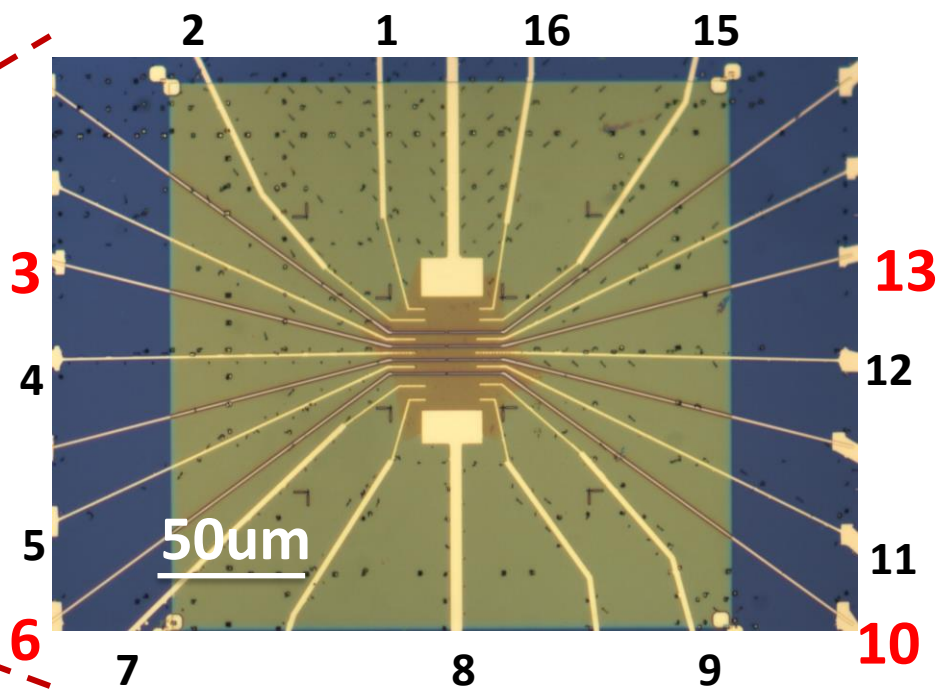
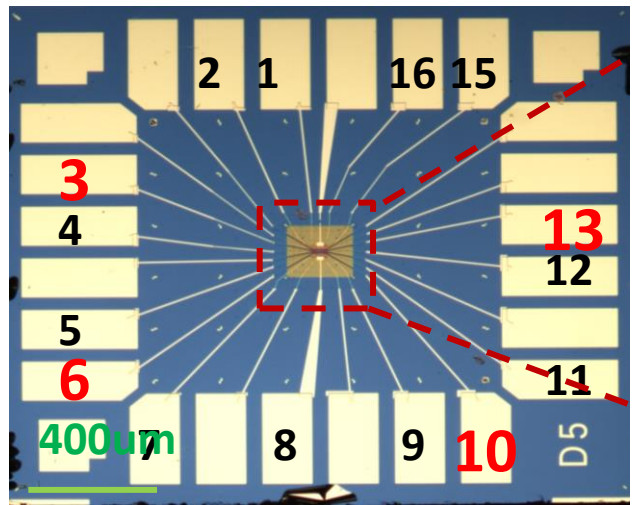
PMMA

SiO<sub>2</sub>

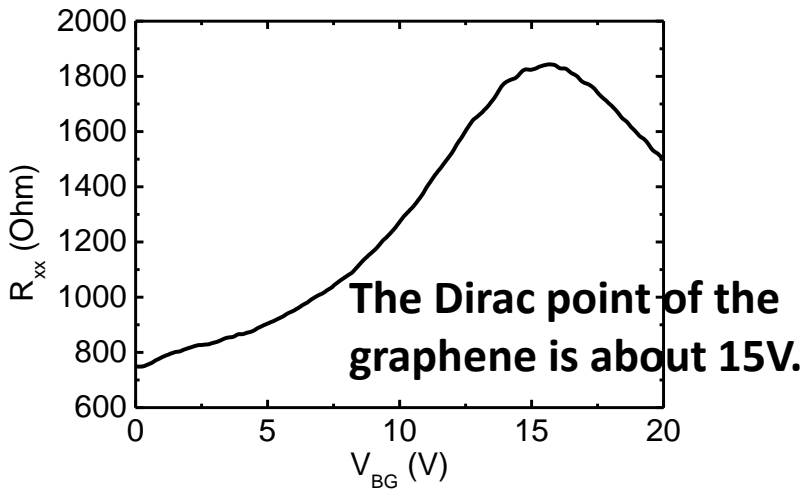
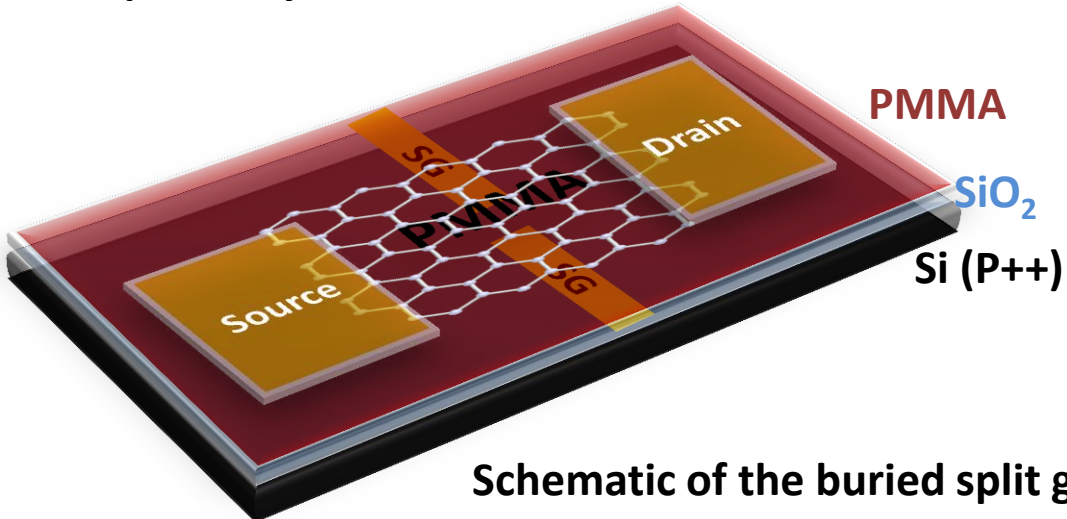
Si (P++)

# The buried split gate device

The optical image of our device



Two out of the four buried split gate devices have been measured in this study. They are SG(6 - 10) and SG(3 - 13), the width of these two pairs split gate are 400nm and 800nm, respectively.

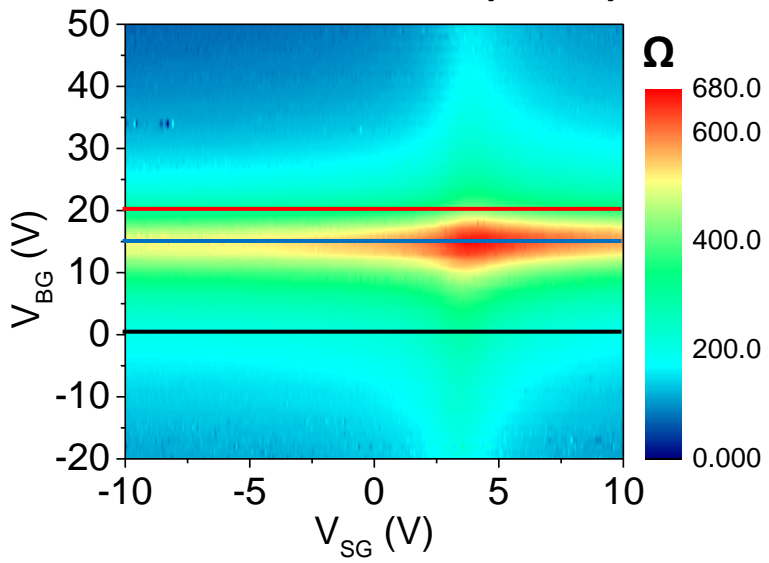


Schematic of the buried split gate device

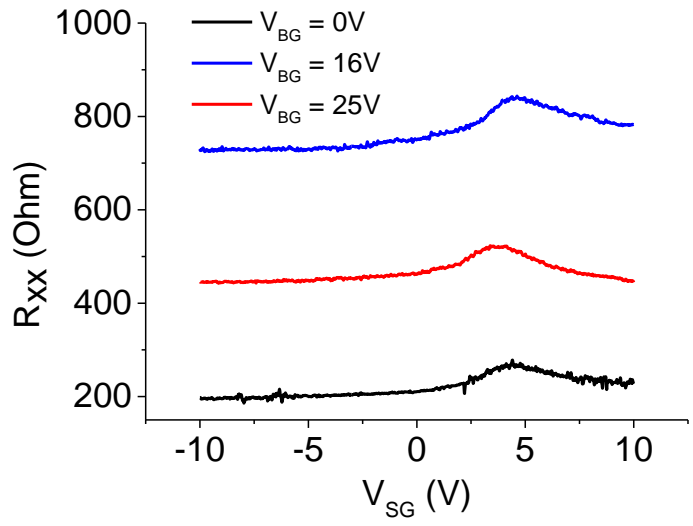
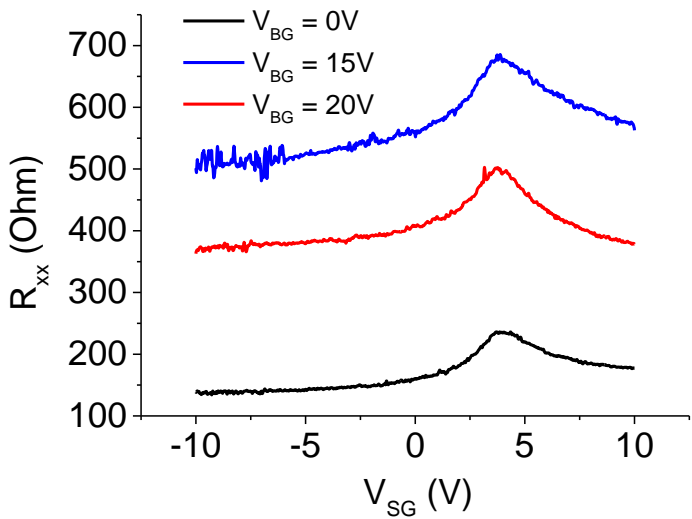
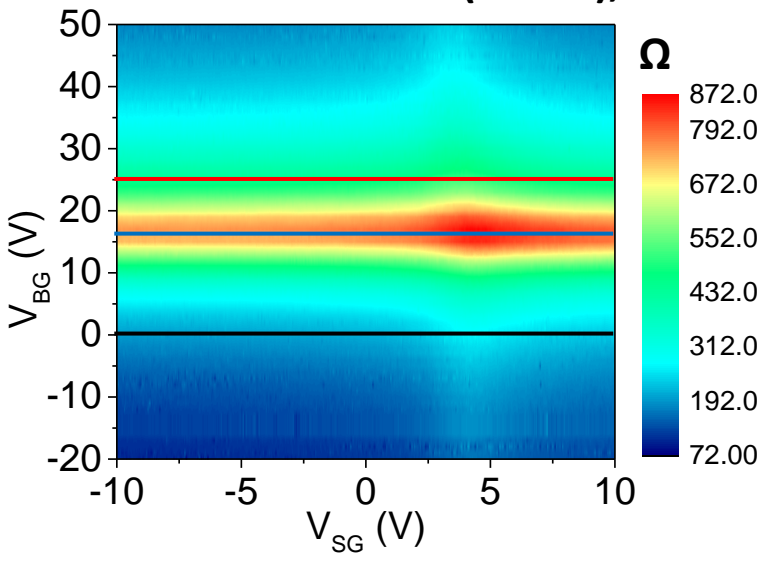
# Transport measurement at B = 0T

B = 0T, T = 0.27K

SG(6 - 10), 400nm

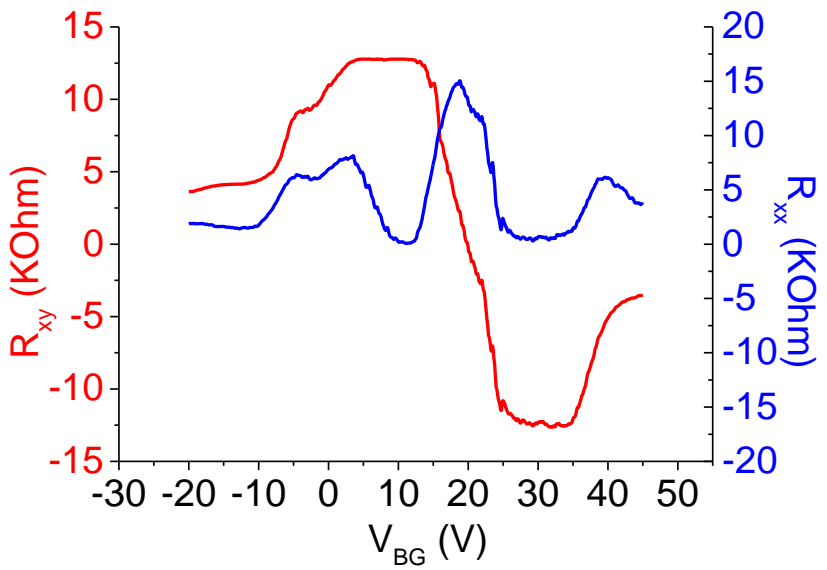
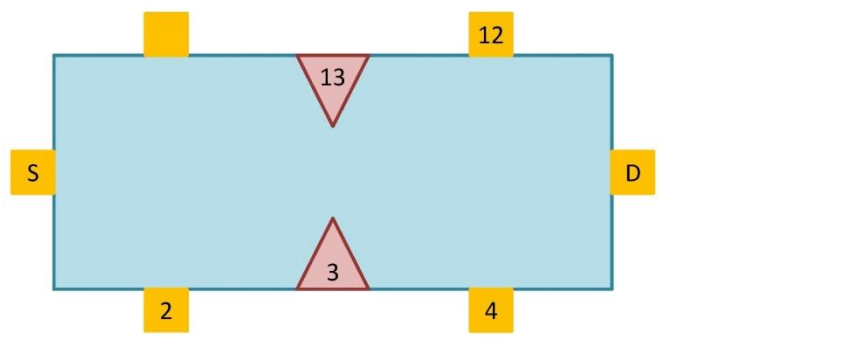


SG(3 - 13), 800nm

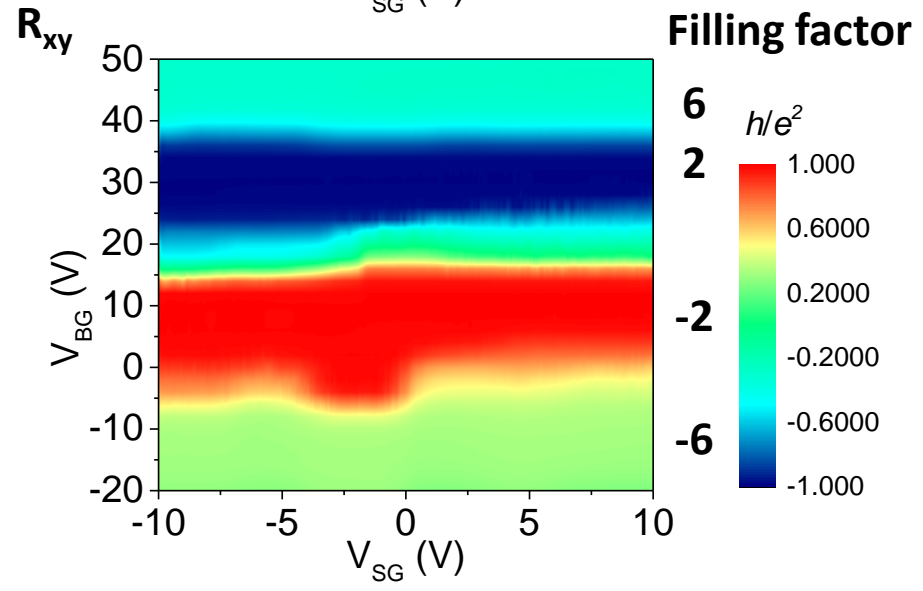
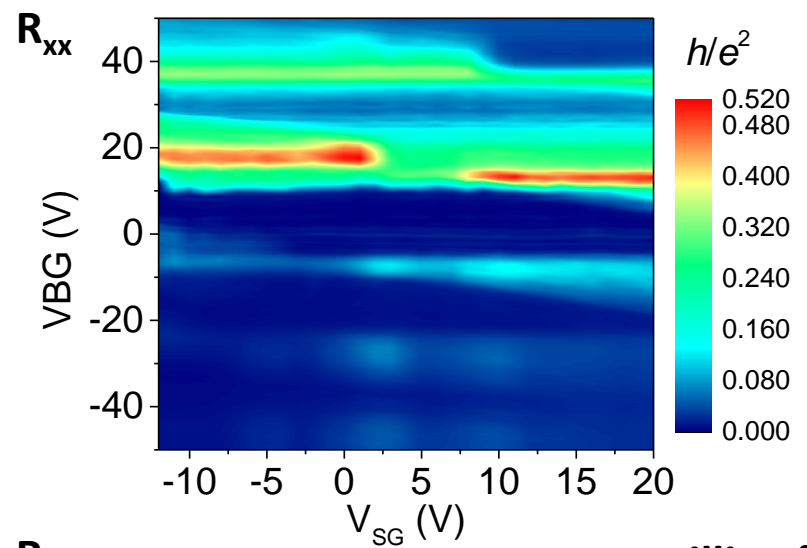


# Transport measurement at B = 10T

B = 10T, T = 0.27K, SG (3-13), 800nm



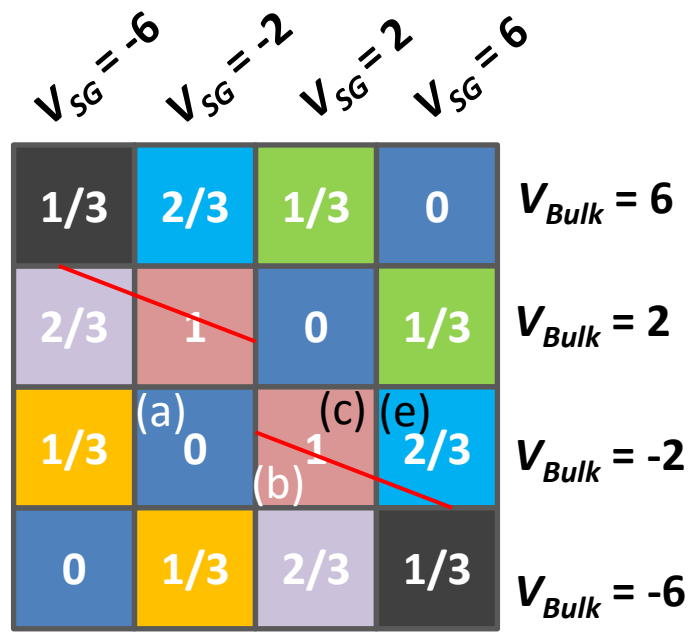
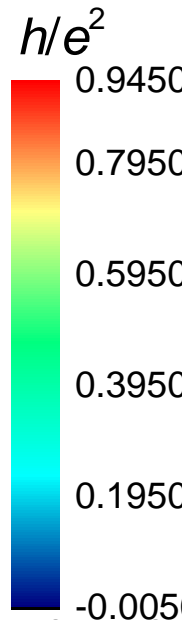
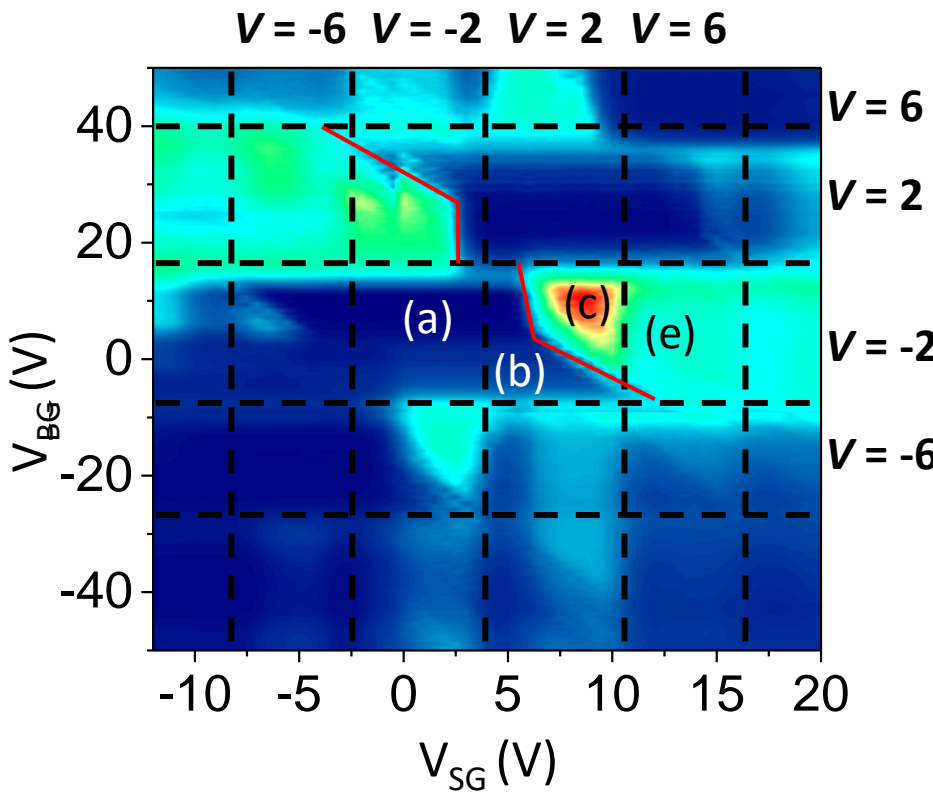
The quantum Hall measurement at  $V_{SG} = 0V$  for SG (3-13)





# Transport measurement at B = 10T

B = 10T, T = 0.27K, SG (6-10), 400nm

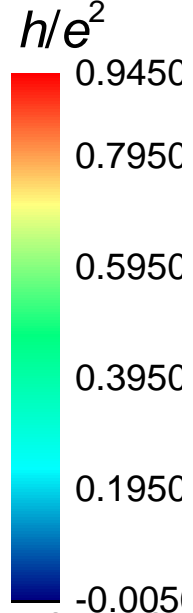
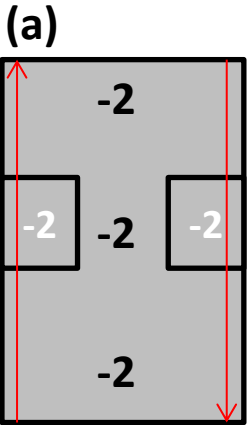
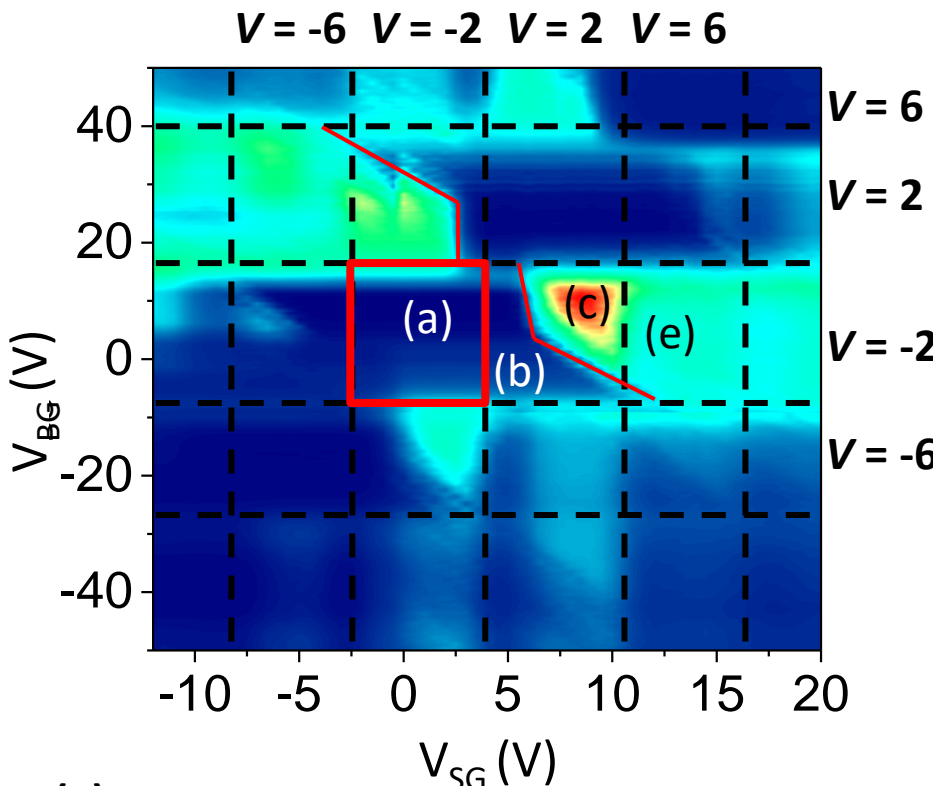


The rectangle of the theoretical calculation

The schematics of current flow corresponding to color map.

# Transport measurement at B = 10T

B = 10T, T = 0.27K, SG (6-10), 400nm



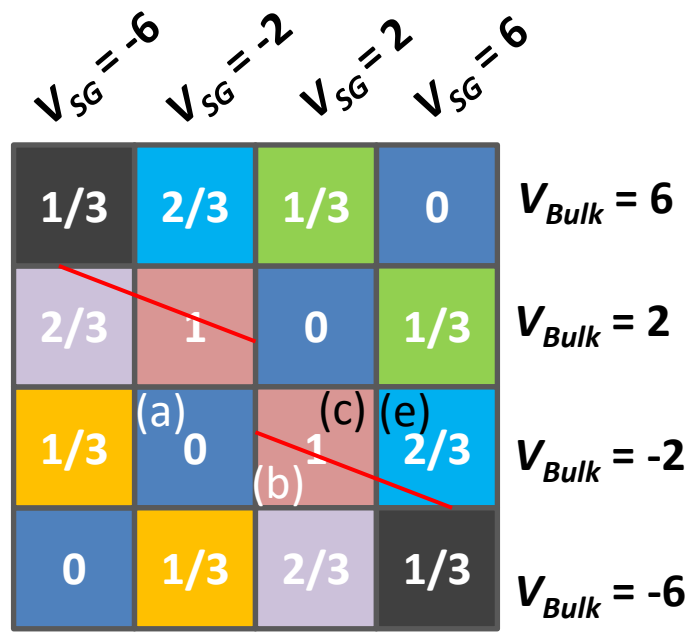
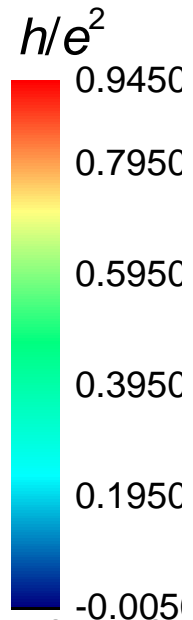
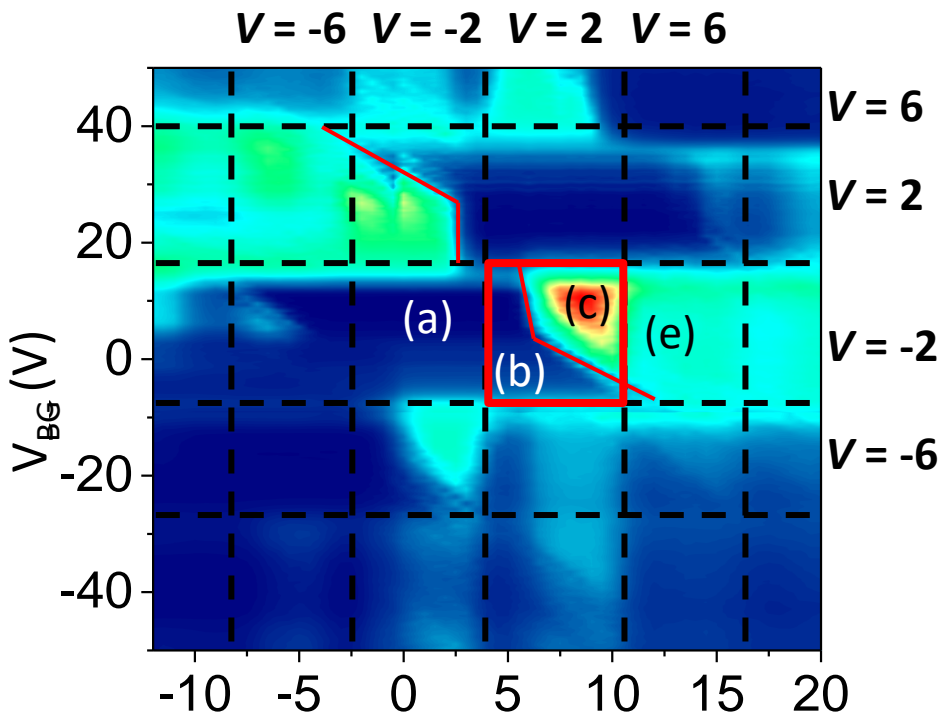
	$V_{SG} = -6$	$V_{SG} = -2$	$V_{SG} = 2$	$V_{SG} = 6$	
$V_{Bulk} = 6$	1/3	2/3	1/3	0	
$V_{Bulk} = 2$	2/3	1	0	1/3	
$V_{Bulk} = -2$	1/3	(a) 0	(c) 1	(e) 2/3	
$V_{Bulk} = -6$	0	1/3	2/3	1/3	

The rectangle of the theoretical calculation

The schematics of current flow corresponding to color map.

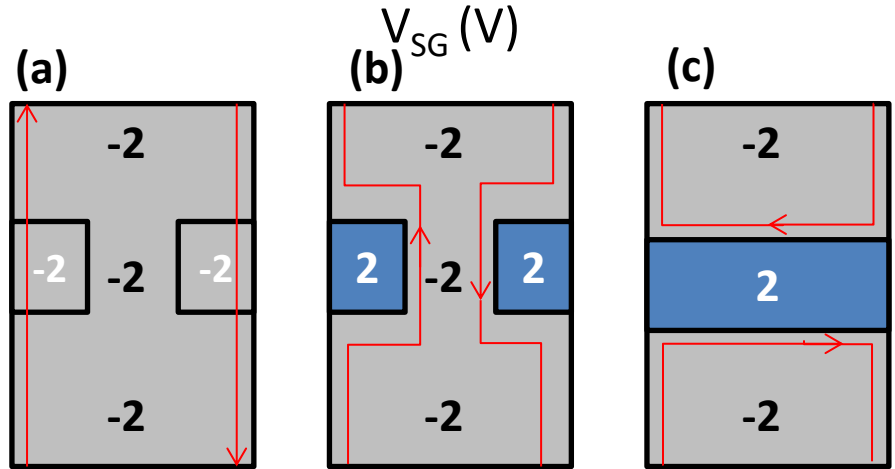
# Transport measurement at B = 10T

B = 10T, T = 0.27K, SG (6-10), 400nm



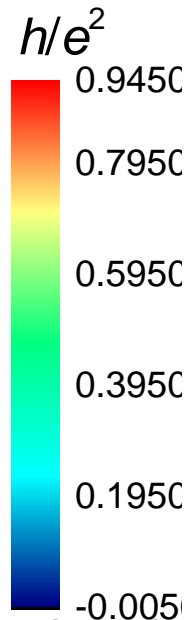
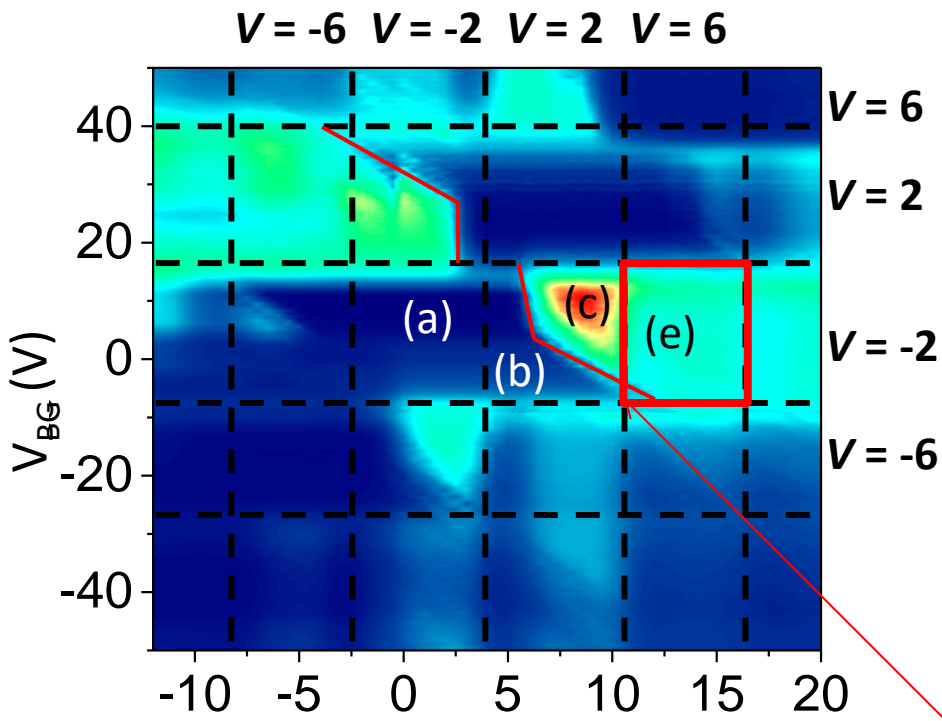
The rectangle of the theoretical calculation

The schematics of current flow corresponding to color map.



# Transport measurement at B = 10T

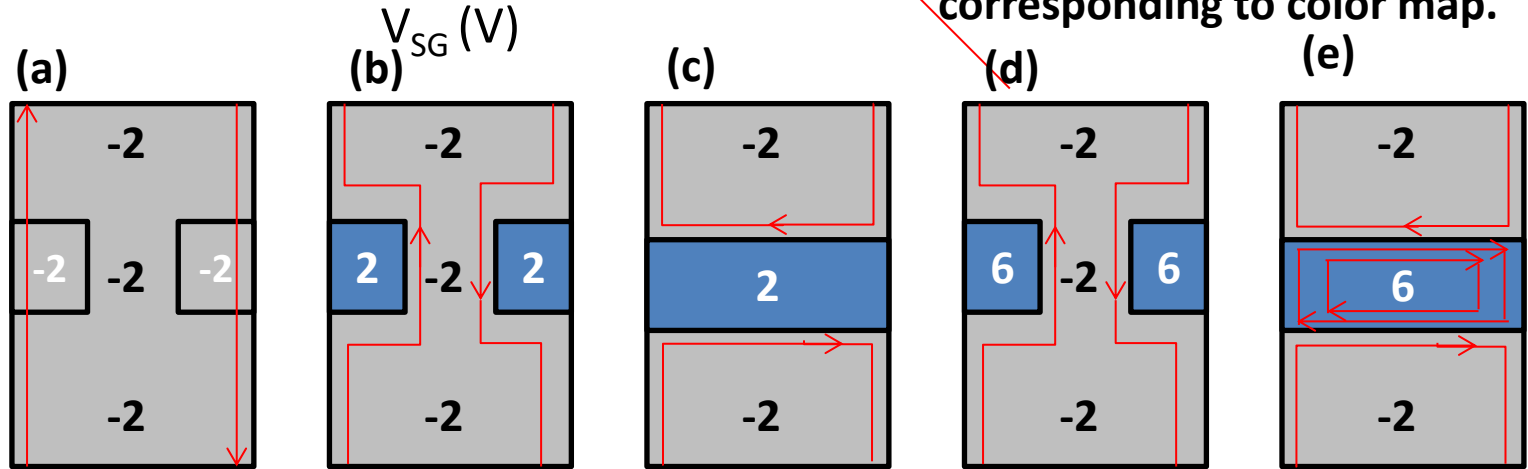
B = 10T, T = 0.27K, SG (6-10), 400nm



	$V_{SG} = -6$	$V_{SG} = -2$	$V_{SG} = 2$	$V_{SG} = 6$	
$V_{Bulk} = 6$	1/3	2/3	1/3	0	
$V_{Bulk} = 2$	2/3	1	0	1/3	
$V_{Bulk} = -2$	1/3	(a) 0	(c) 1	(e) 2/3	
$V_{Bulk} = -6$	0	1/3	2/3	1/3	

The rectangle of the theoretical calculation

The schematics of current flow corresponding to color map.



- **Basics of Scanning Gate Microscopy (SGM)**
- **0.7 Anomaly in a Quantum Point Contact**
- **Ongoing Activities**
  - **Graphene Nanoribbons**
  - **Split Gates in Graphene**
  - **Phosphorene**
  - **Hybrid (S-N-S) Systems**



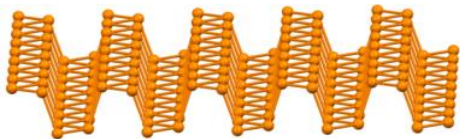
# Weak localization in phosphorene



Francesca Telesio

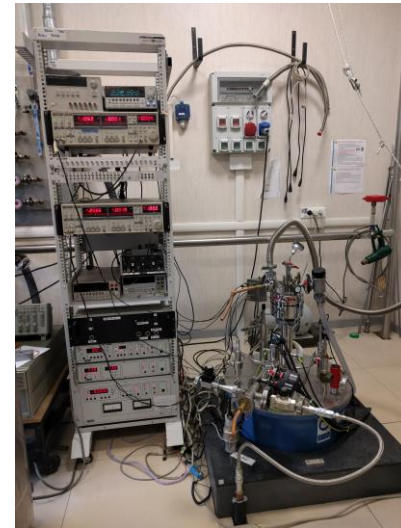
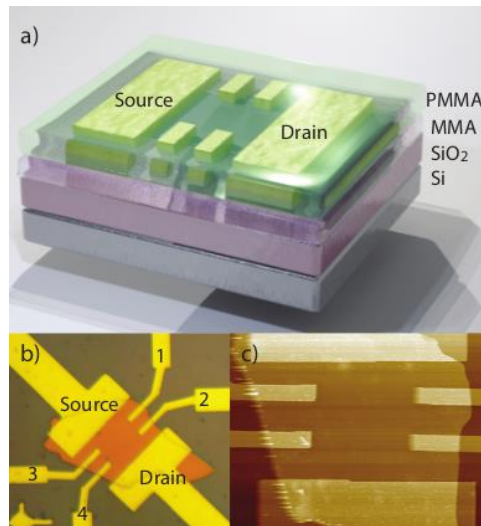
Phosphorene is a recent 2D material, obtained by exfoliation from black phosphorus.

It has a layered puckered structure.



Differently from graphene, it is a semiconductor with gap dependent from the number of layer (from 0.3eV in bulk to 2eV for the monolayer).

Our study is about low temperature magnetotransport on an Hall bar device made with a phosphorene flake.



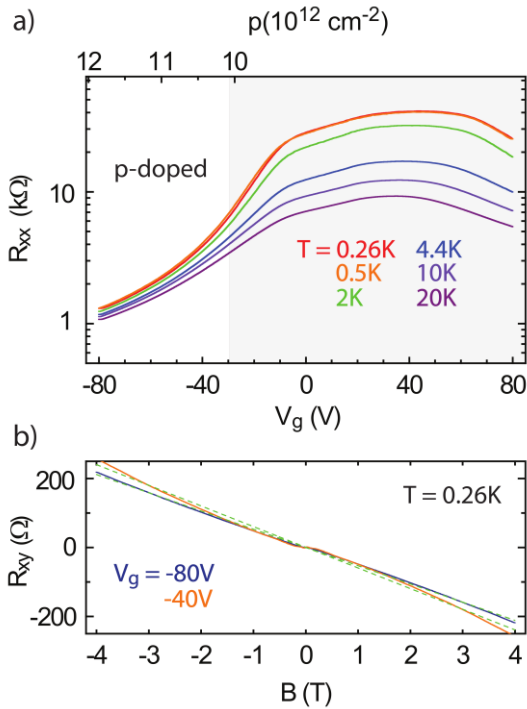
Temperature down to 0.26K  
Magnetic field up to 14T



# Weak localization in phosphorene

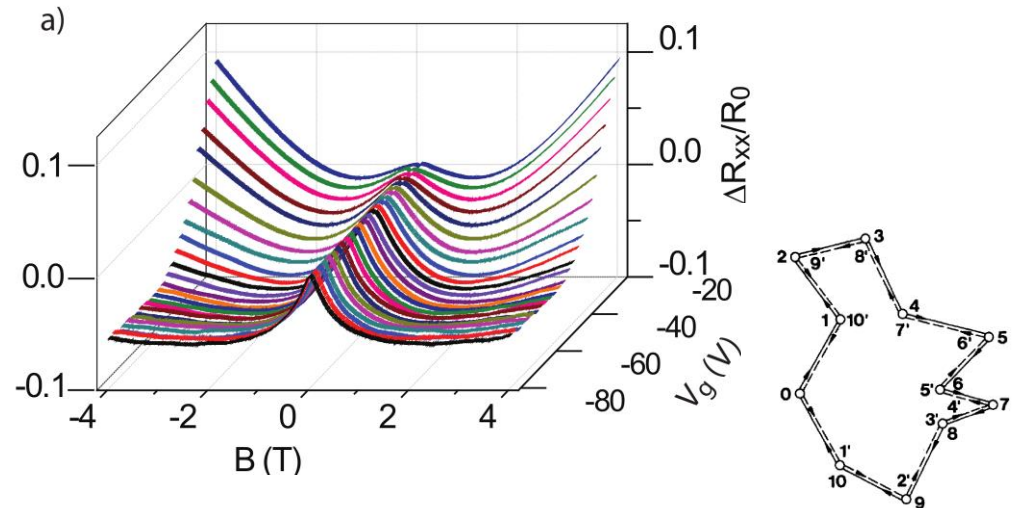


Francesca Telesio



At negative bias voltage we are in hole doped regime, while increasing bias voltage towards positive voltages we go through the band gap.

Weak localization is a quantum effect related to coherent scattering at low temperatures.

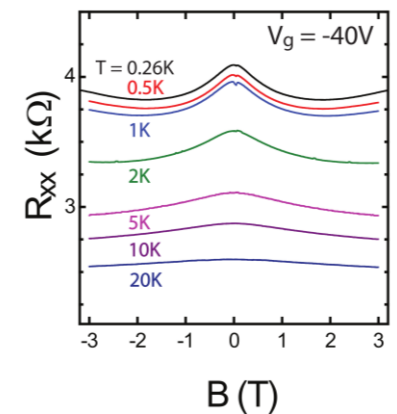
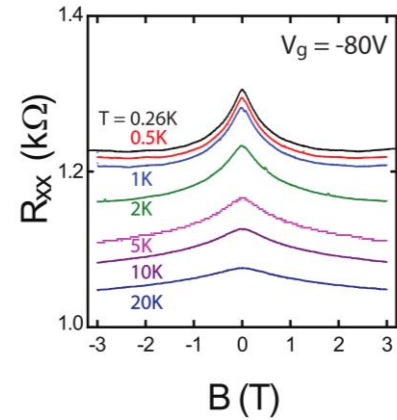


A peak in magnetoresistance at low field is a signature of weak localization.

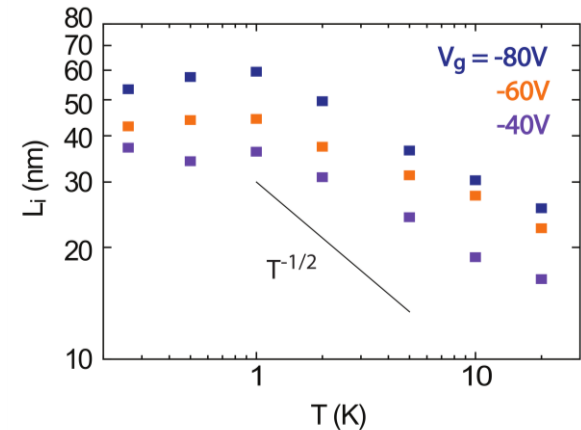
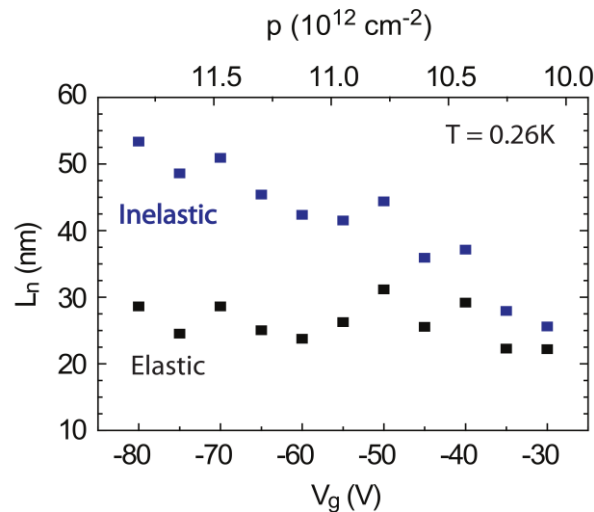
Picture from Bergmann, Weak localization in thin films, Physics Reports 107, 1984

# Weak localization in phosphorene

The low field peak can be fitted with Hikami-Larkin-Nagaoka model in order to extract information on scattering times.



Since it's a coherence effect, it's suppressed by temperature.



Further analysis is in progress...

Collaboration with CNR-ICCOM that provided the bP (PHOSFUN ERC project) and McGill University, Montreal



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# Funding

